



FLORIDA STATE UNIVERSITY

Plasmonic Metal Oxide Nanocrystals

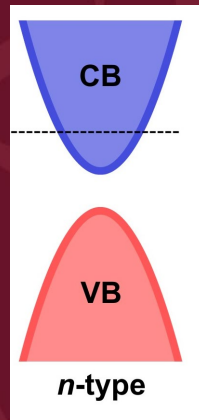
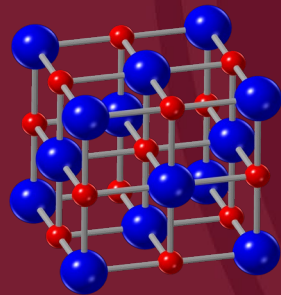
How a Semiconductor acts like a metal

Geoffrey F. Strouse

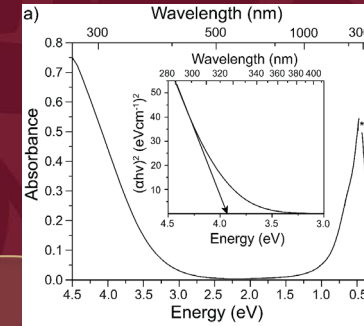
gstrouse@fsu.edu



NSF-DMR #1905757



UV-VIS-NIR



Defect Engineering

$V_{M/O}$

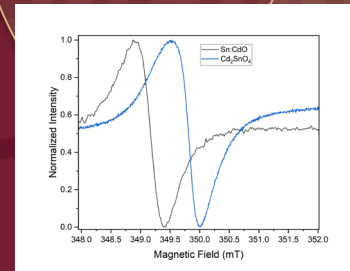
M/O_i

$M2_{M1}$ (antisite)

carrier density

$n \sim 10^{19} - 10^{21}$ carriers / cm^3

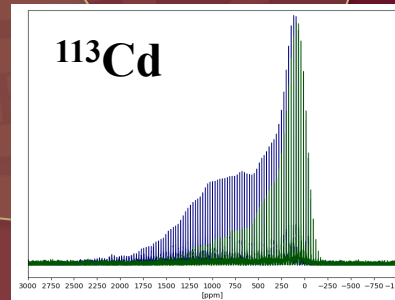
MO_x



EPR

carrier type/ mass

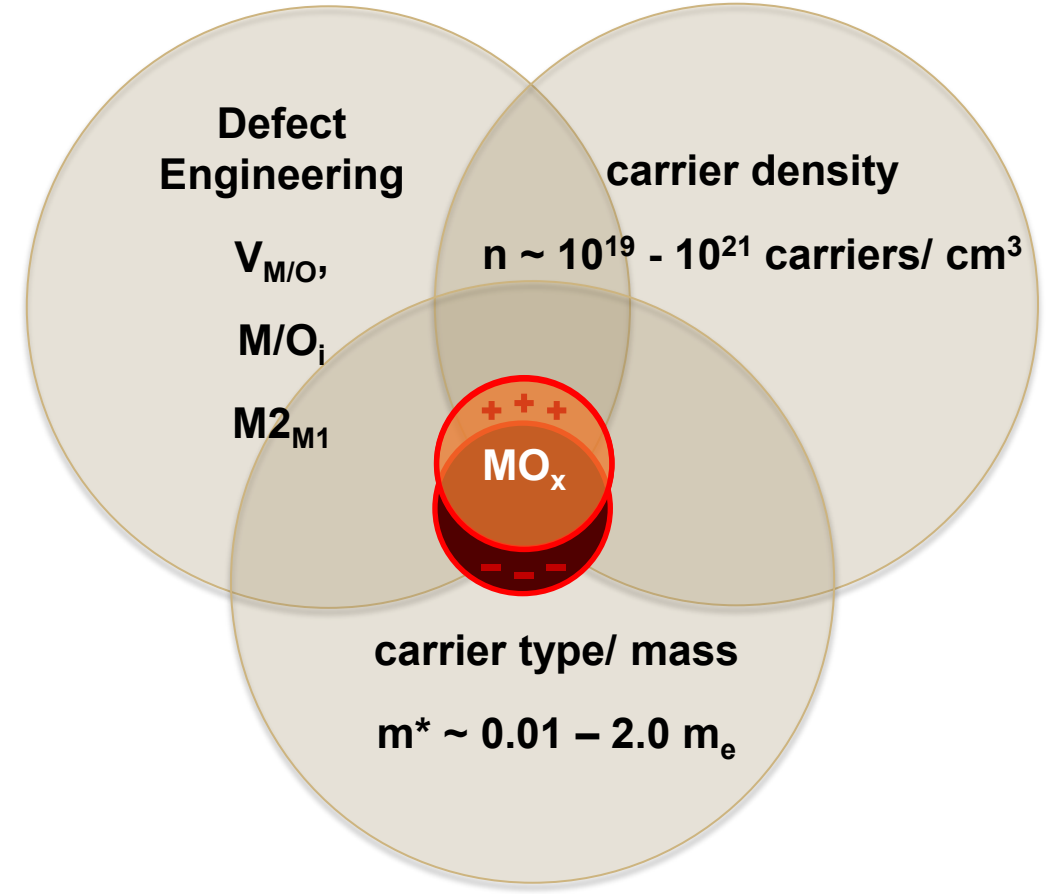
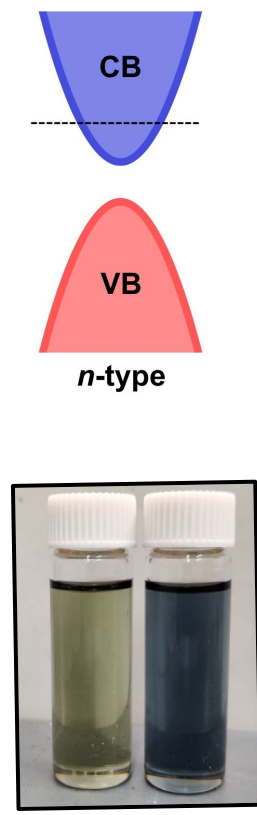
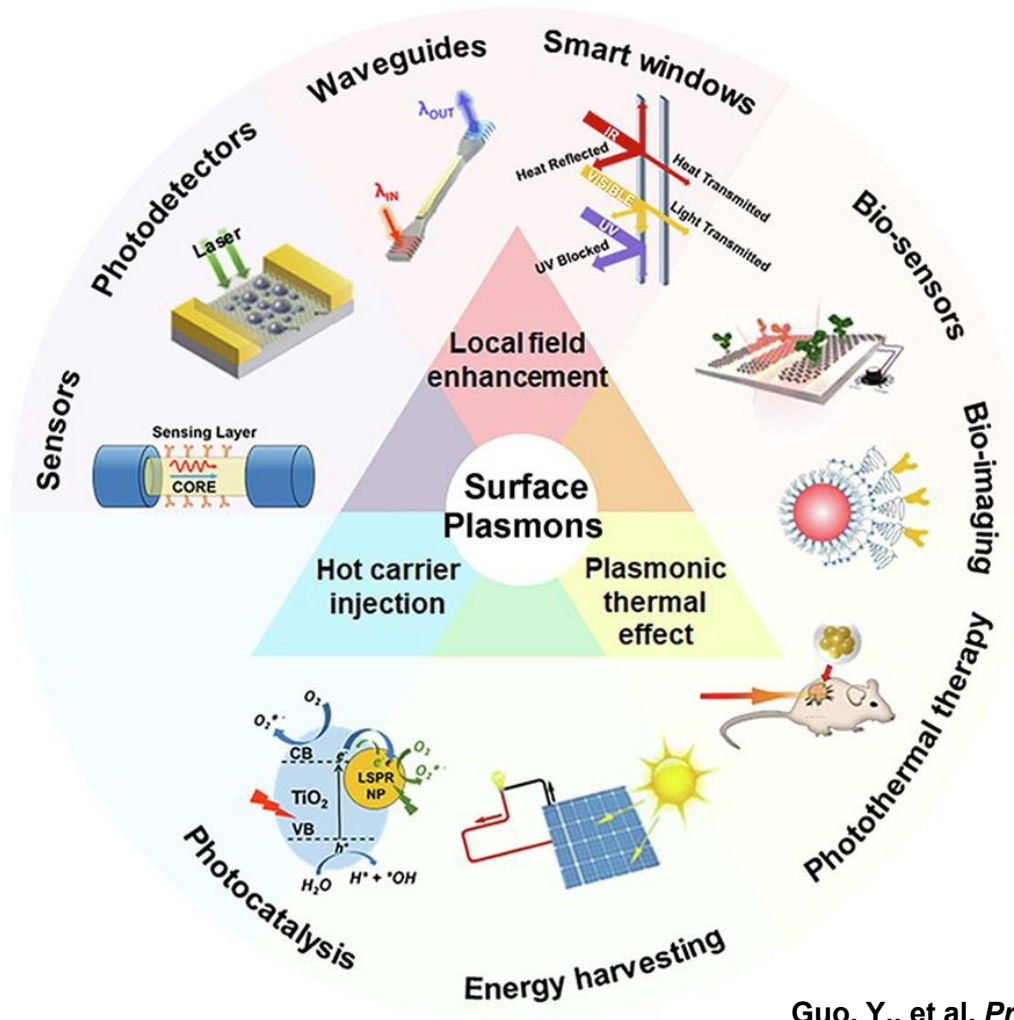
$m^* \sim 0.01 - 2.0 m_e$

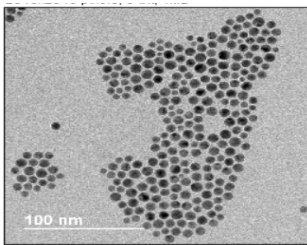
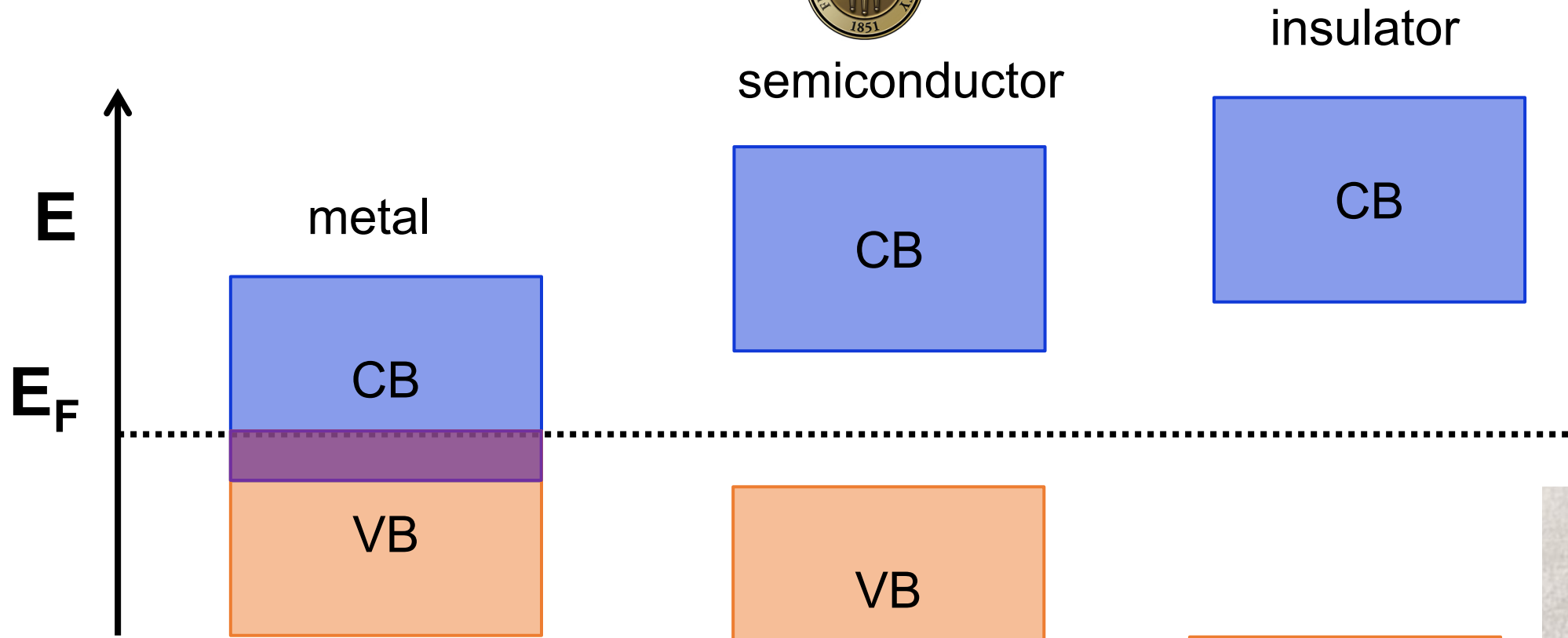


NMR

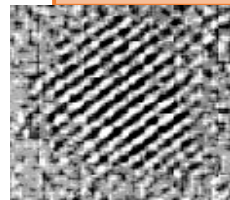


Plasmonic MO_x Semiconductor Nanocrystals

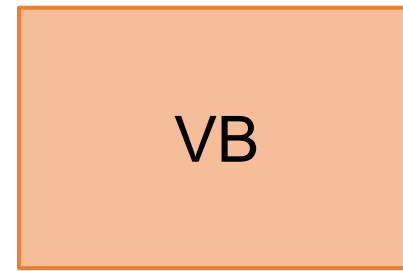




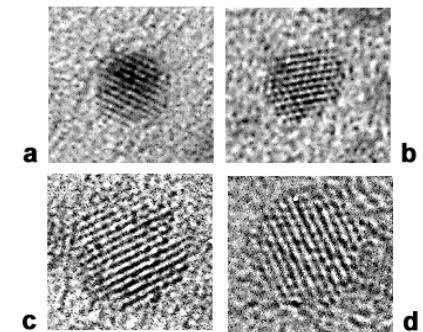
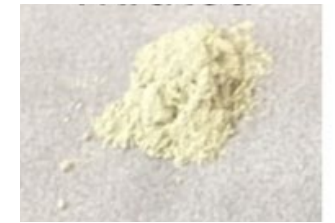
Au



CdSe



In₂O₃



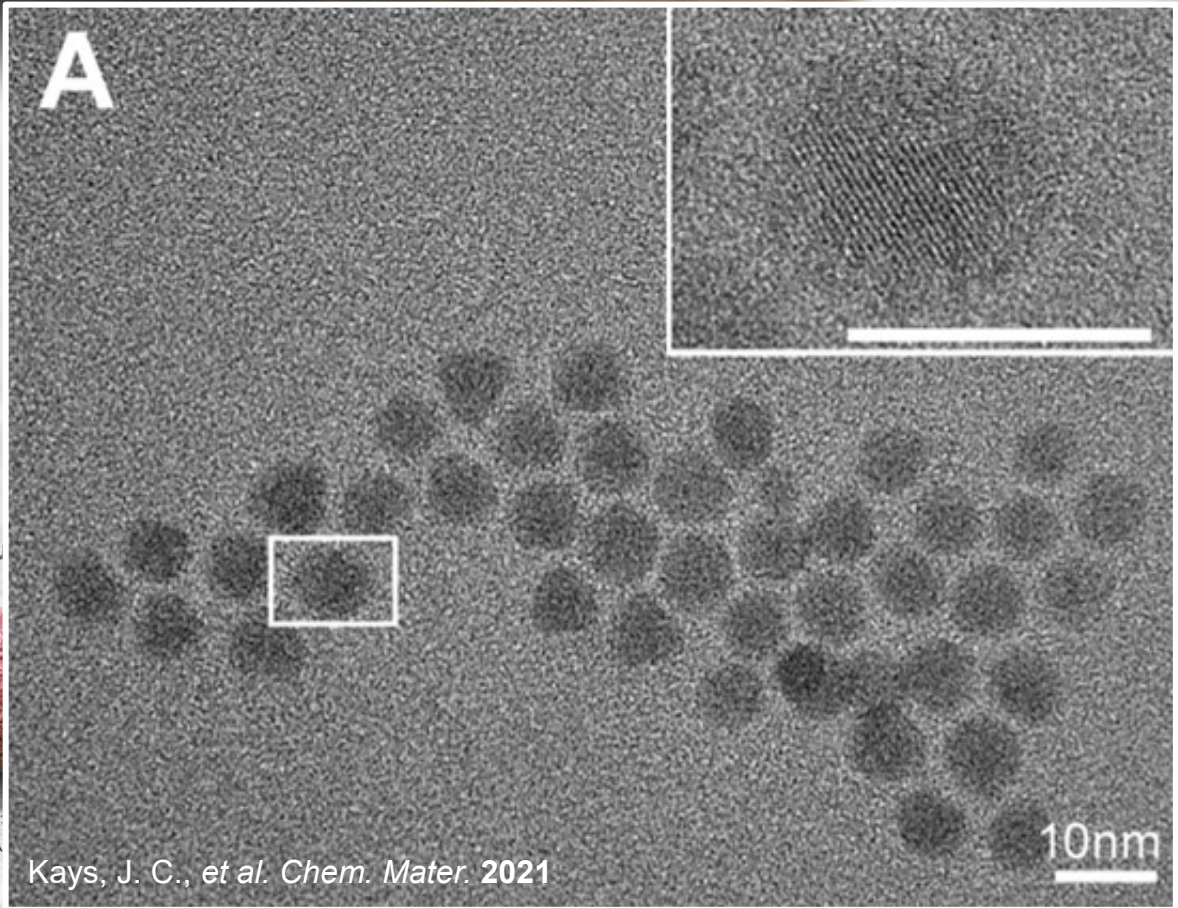
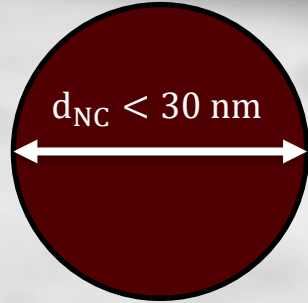
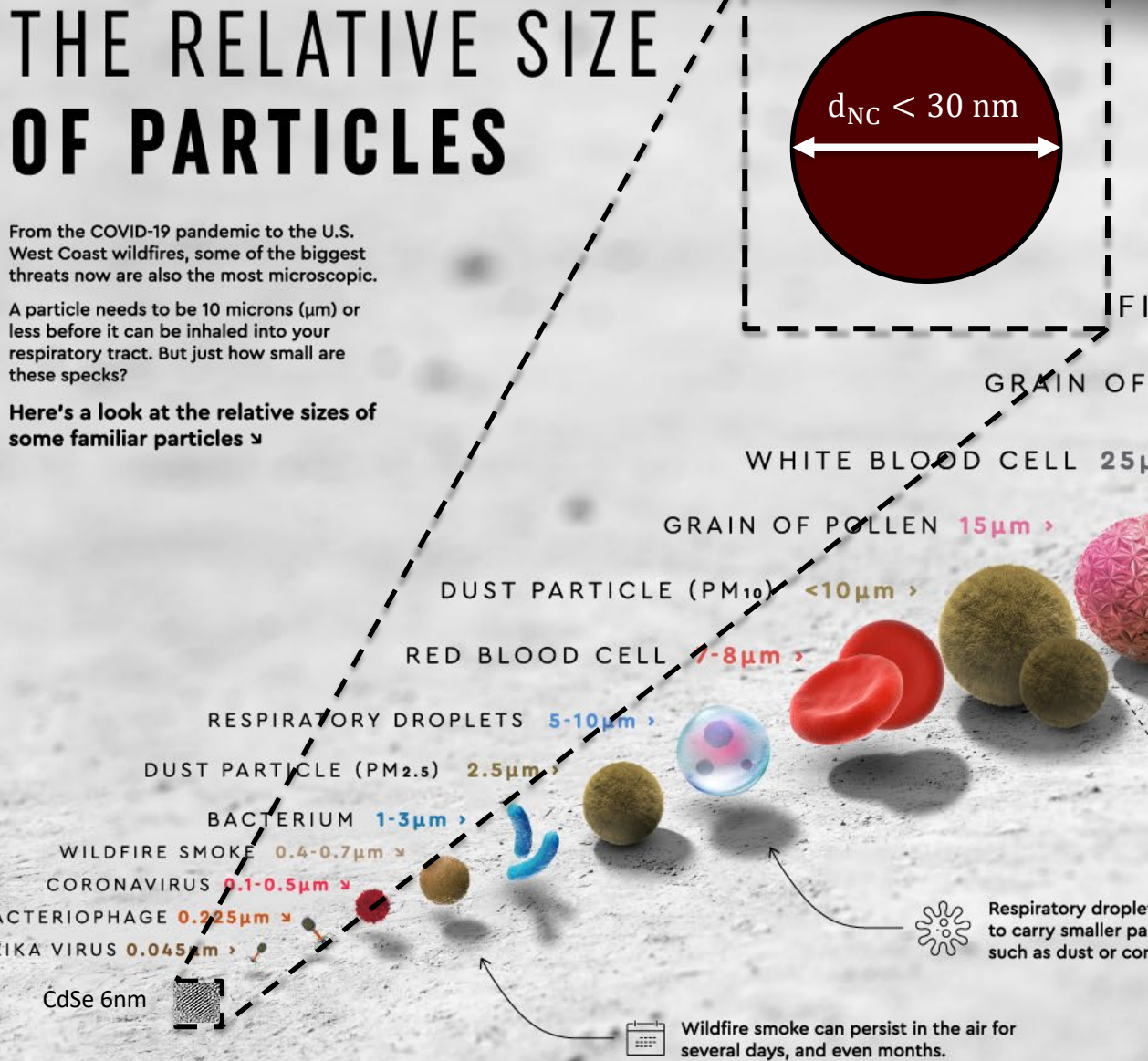
5 nm

THE RELATIVE SIZE OF PARTICLES


From the COVID-19 pandemic to the U.S. West Coast wildfires, some of the biggest threats now are also the most microscopic.


A particle needs to be 10 microns (μm) or less before it can be inhaled into your respiratory tract. But just how small are these specks?

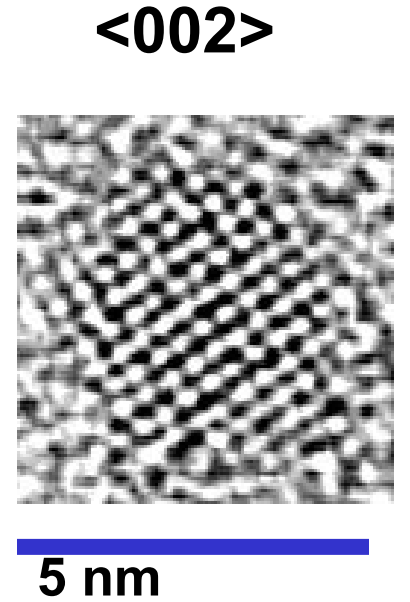
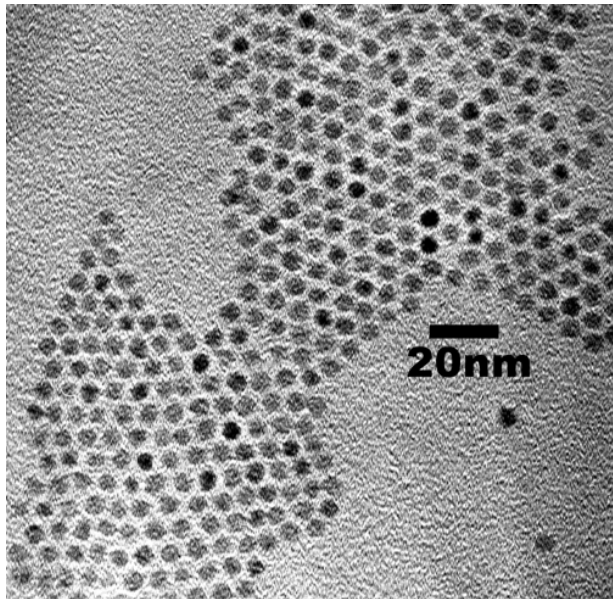
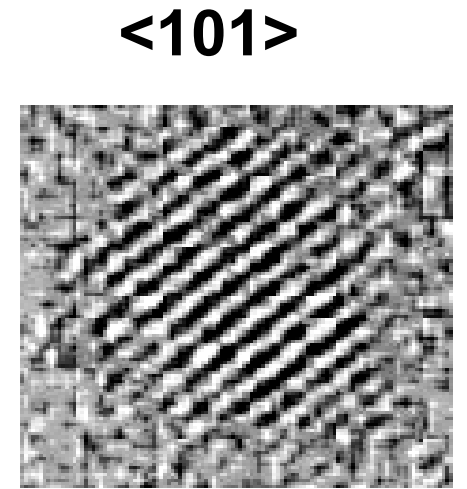
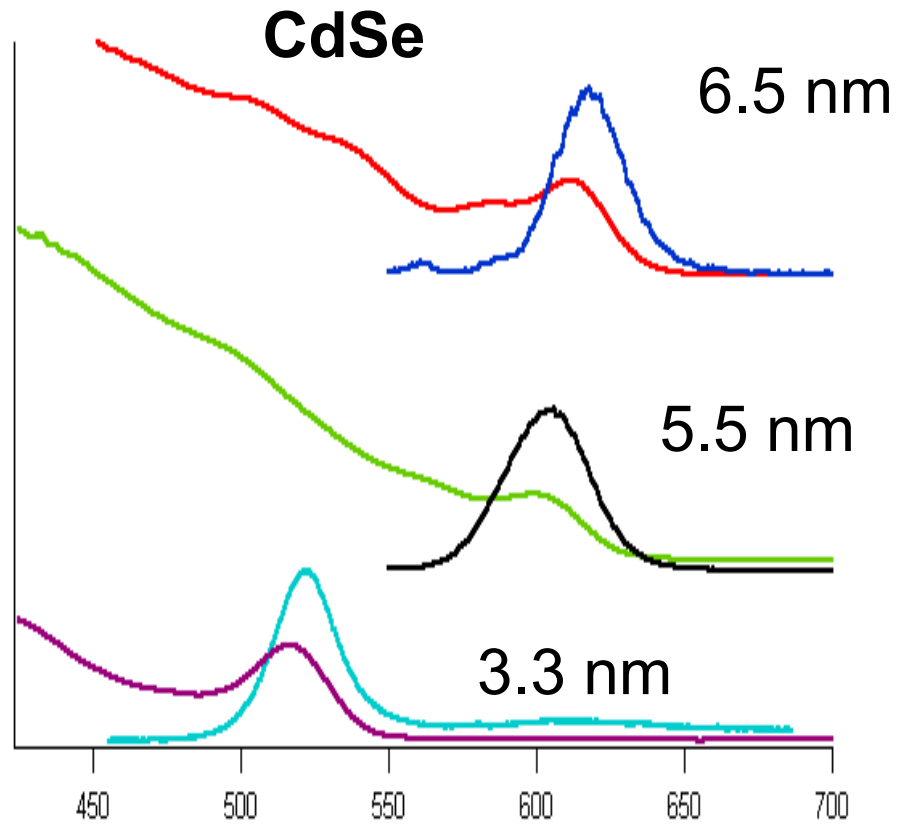
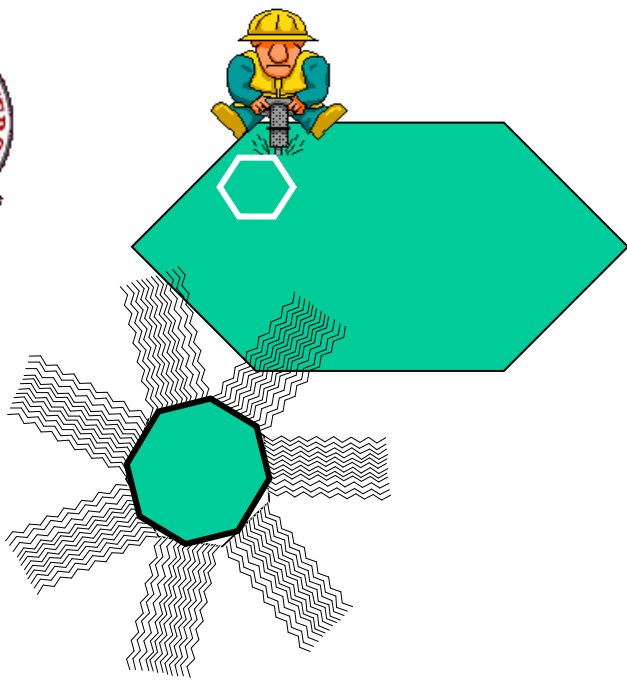
Here's a look at the relative sizes of some familiar particles \blacktriangleright

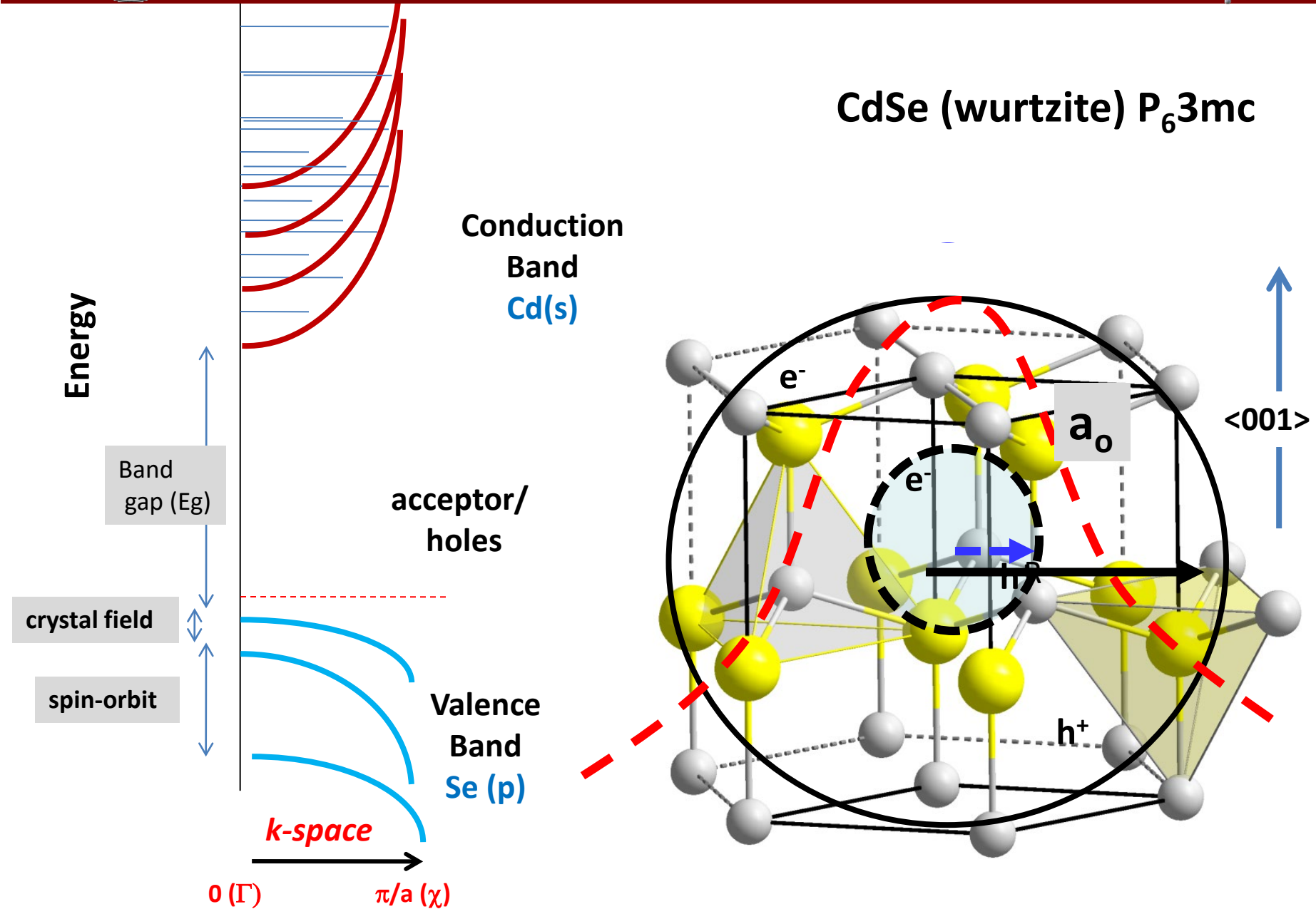


The visibility limits for what the naked eye can see hovers around 10-40 μm .

 Respiratory droplets have the potential to carry smaller particles within them, such as dust or coronavirus.

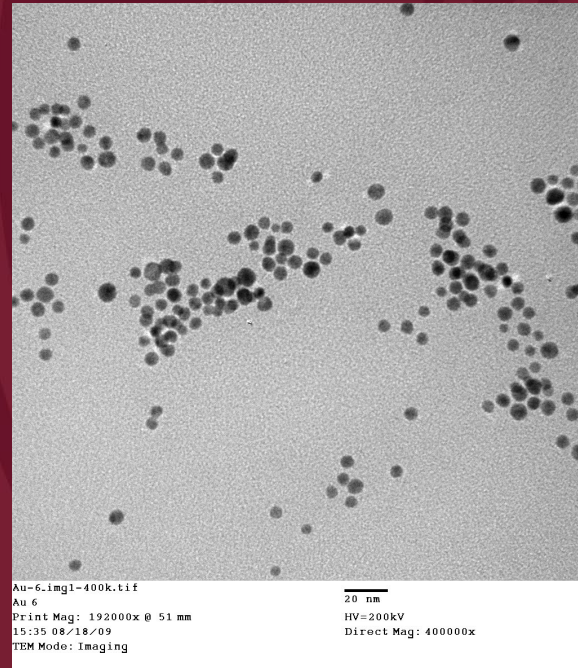
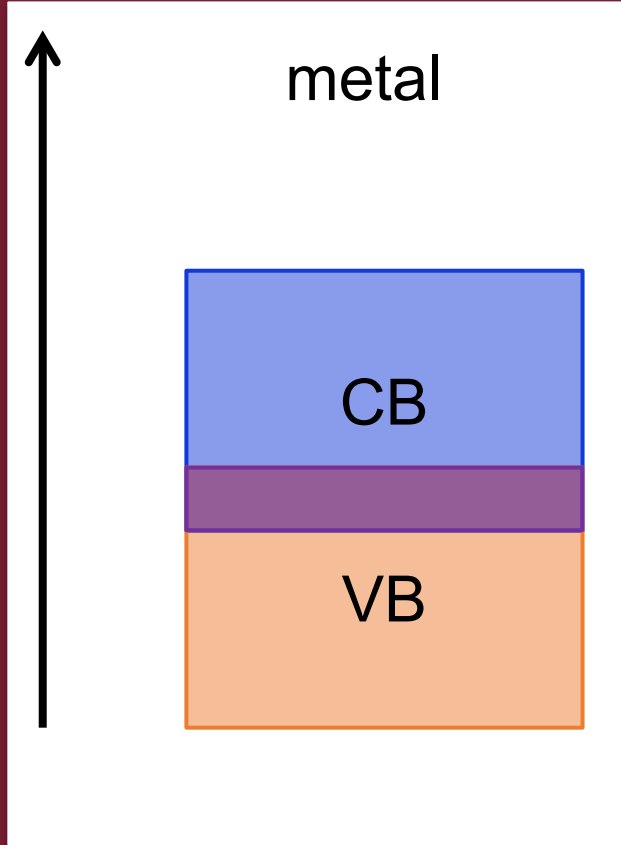
 Wildfire smoke can persist in the air for several days, and even months.



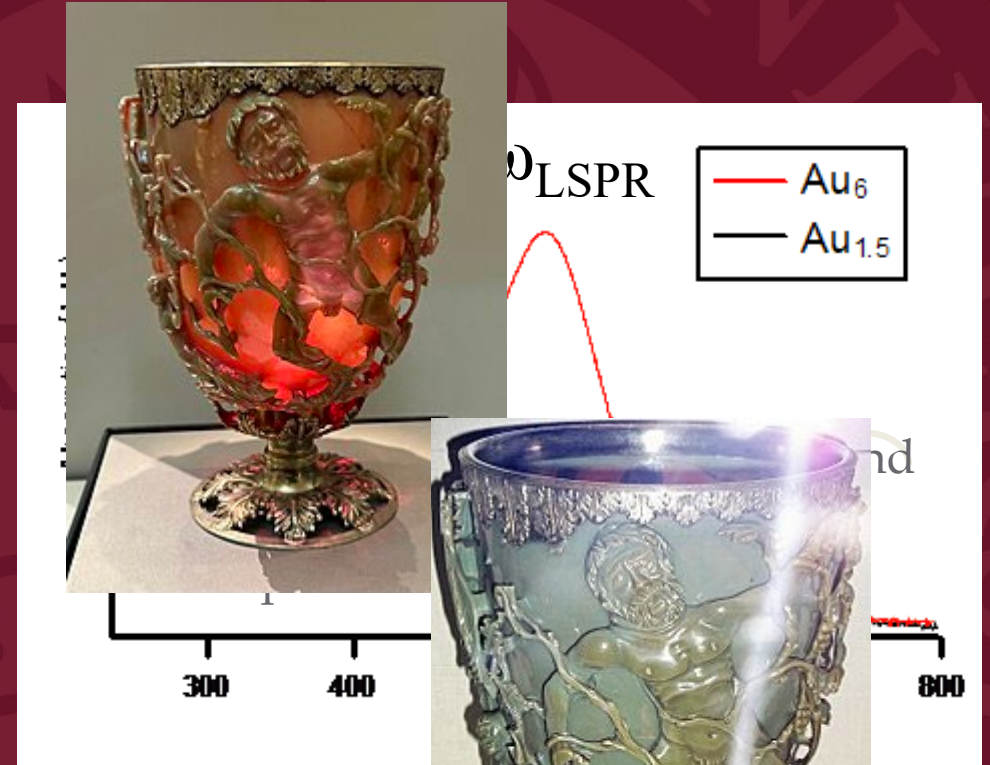




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LSPR Extinction Spectra for Au



Lycurgus cup, 5th century



Plasmons, Photons, and Permittivity, Oh my

The Dielectric Function

(relative permittivity)

$$\epsilon_r(\omega) = \epsilon_r'(\omega) + i\epsilon_r''(\omega)$$

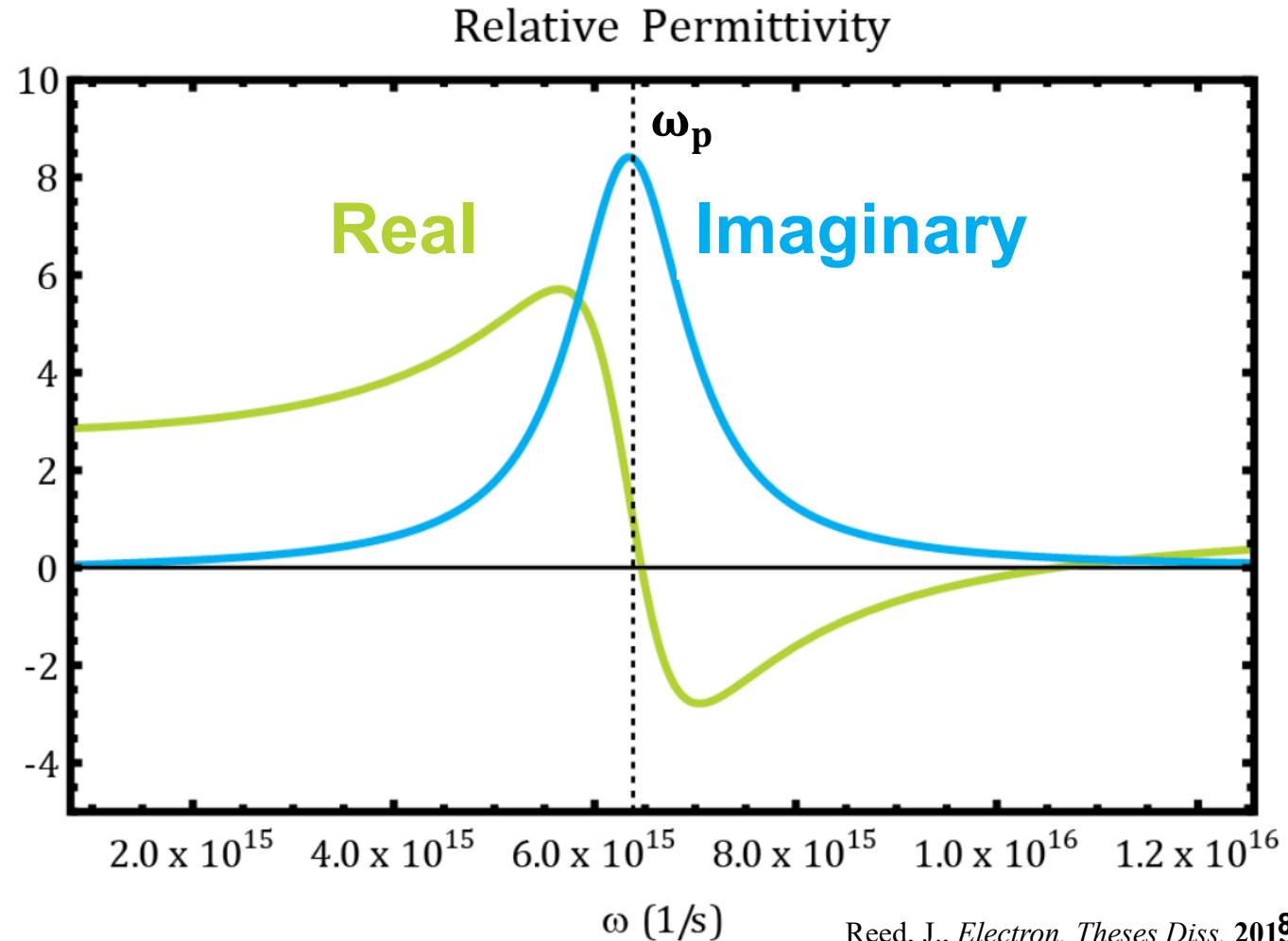
$\epsilon_r(\omega)$ describes the interactions of materials with applied electric fields.

$$\epsilon_r(\omega) = \epsilon_\infty - \frac{\omega_p^2}{\omega^2 + \underbrace{i\omega\Gamma}_{\text{size dependent damping}}} \quad \omega_p^2 = \frac{ne^2}{\epsilon_0 m^*}$$

$\epsilon_r', \epsilon_r''$ unitless

Maximum extinction arises at maximum ϵ_r'' .

Here, a resonance condition is met

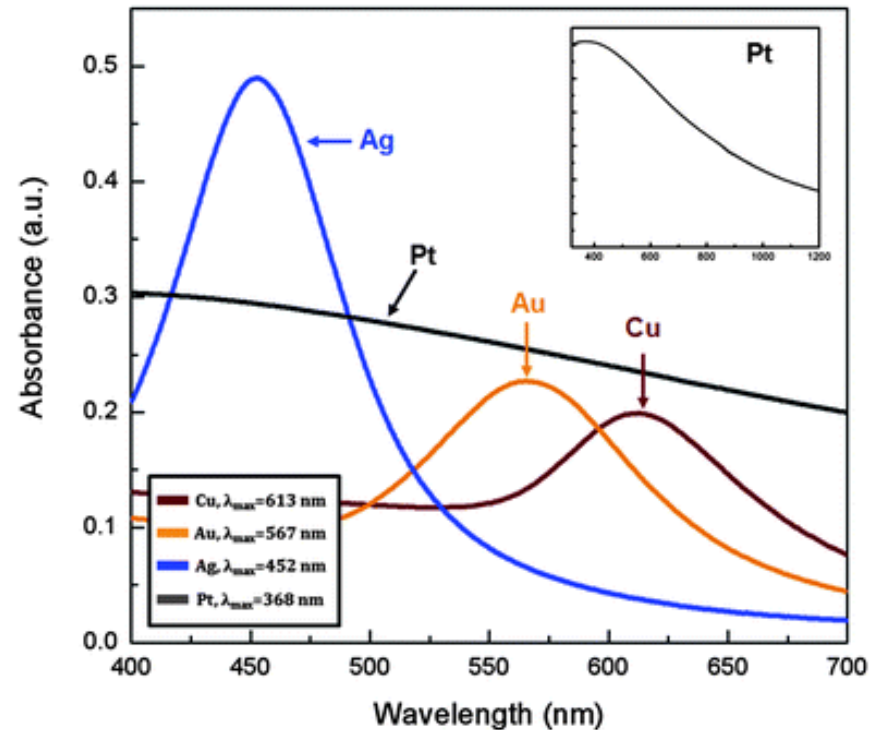
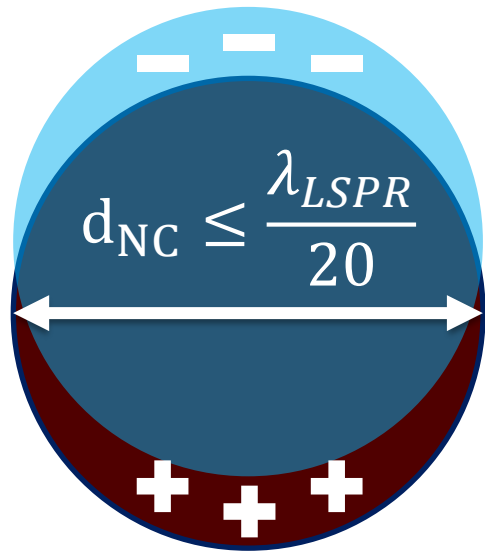




Metals: Localized Surface Plasmon Resonance (LSPR)

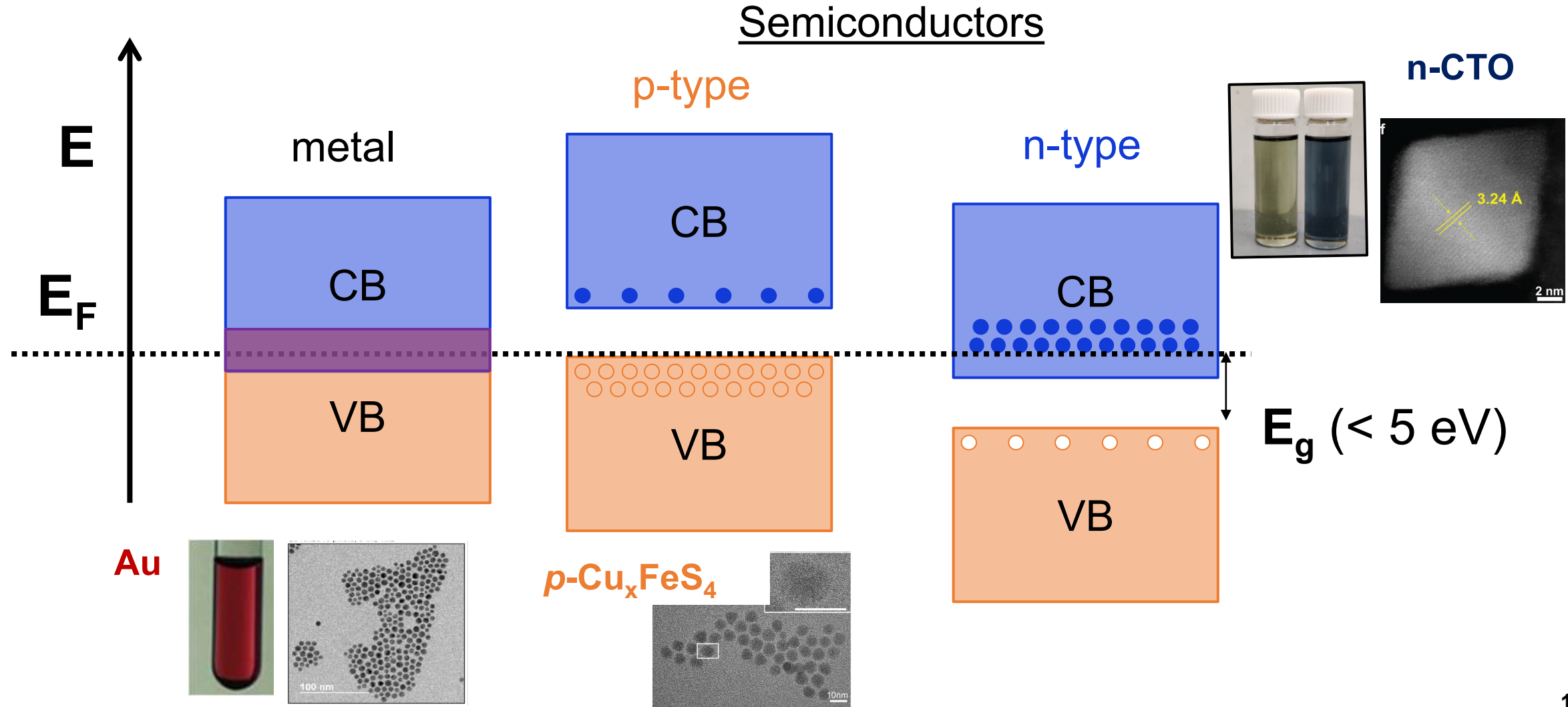
Nobel Metals (metallic)

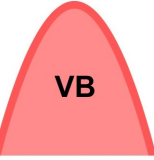
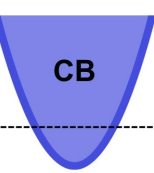
Shin, D. O., *et al.*, *J. Mater. Chem.*, 2010





Plasmons require carriers (or electrons) above the Fermi Energy Level

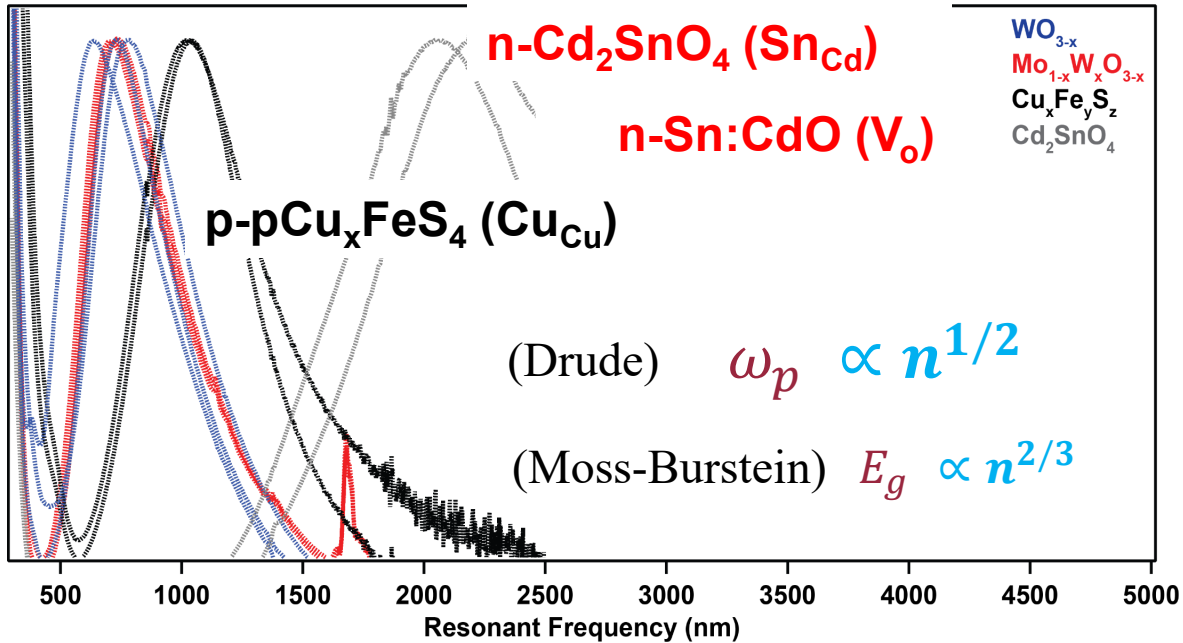




n-type

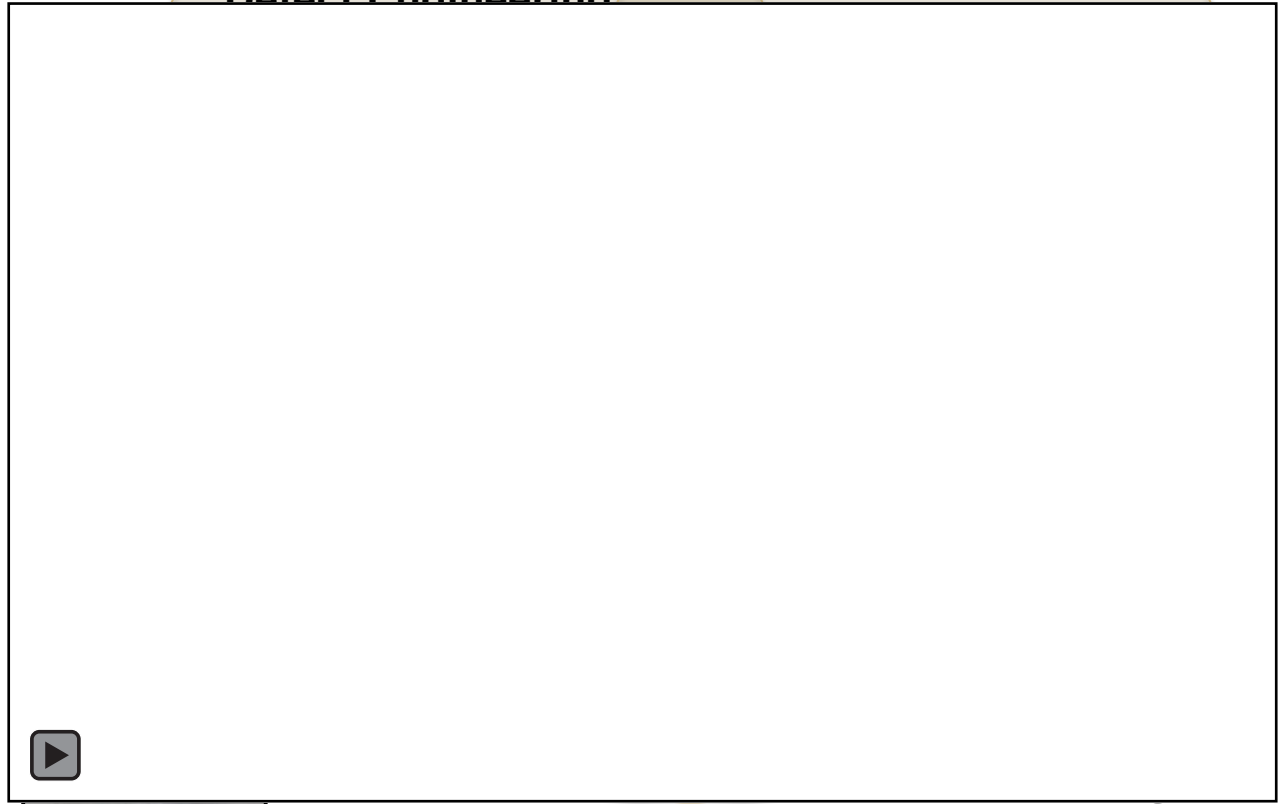
Plasmonic Semiconductor Nanocrystals (PSNC)

n-WO_{3-x} (V_O)



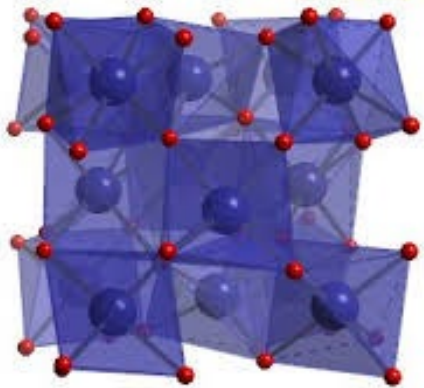
Collective oscillation of free carriers at a
 plasma frequency, ω_p
 carrier density

Defect Engineering



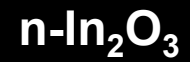


indium(III) oxide



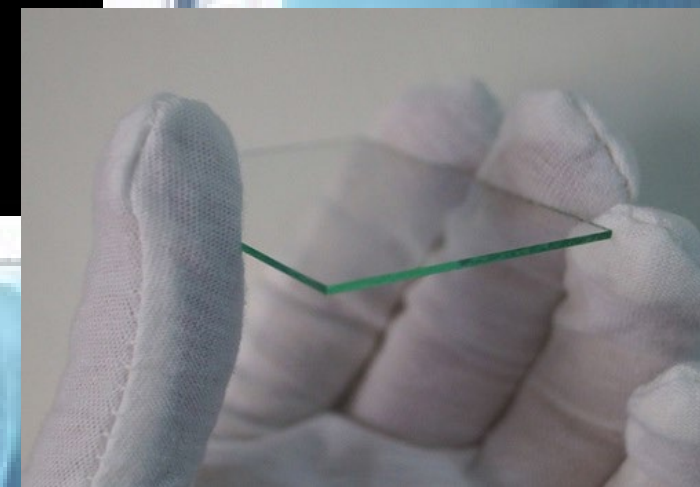
Conducting glass: an industrial standard

Indium-Tin Oxide



ITO

V_o and Sn_{In} lead to n-doping



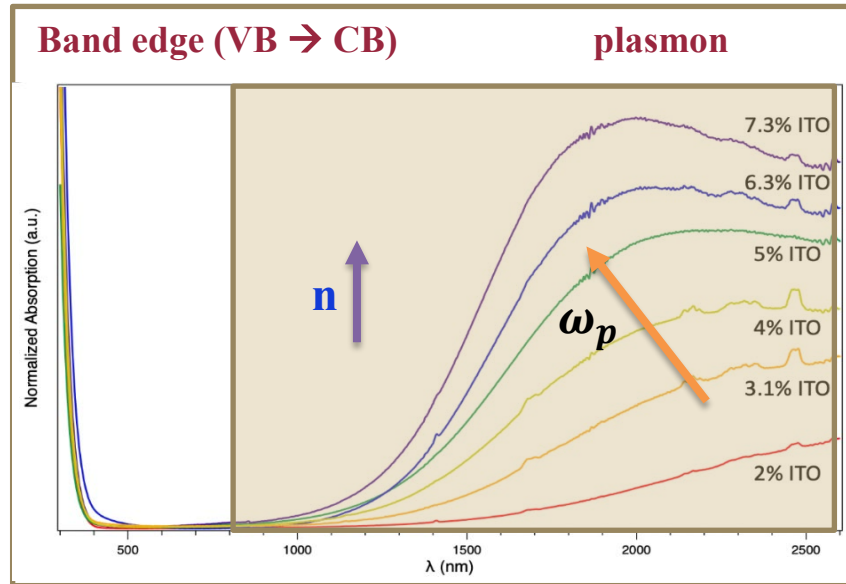
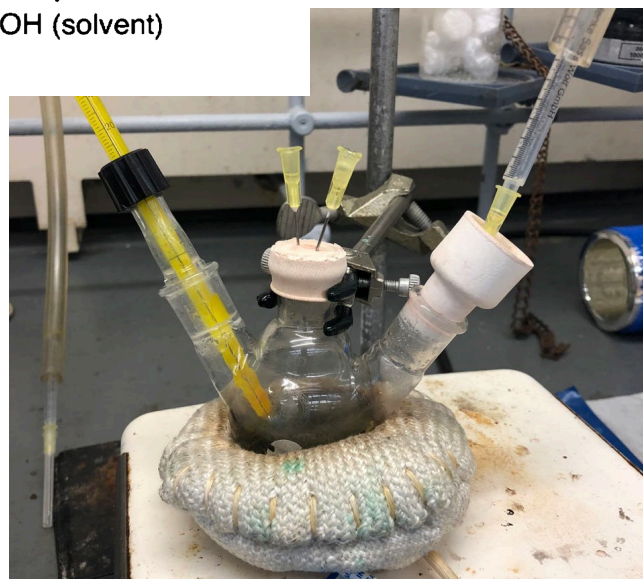
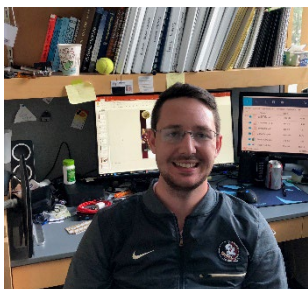
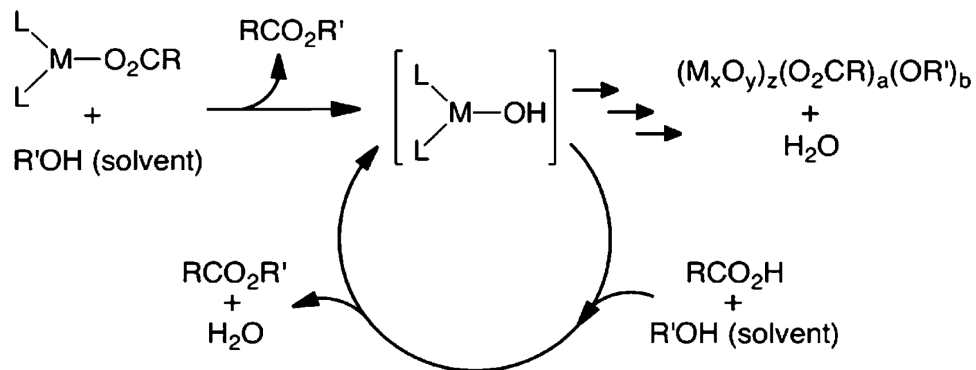


Carrier Density, Effective Mass, and Nuclear Relaxation Pathways in Plasmonic Sn:In₂O₃ Nanocrystals

Carl R. Conti III, Giovanni Quiroz-Delfi, Joanna S. Schwarck, Banghao Chen, and Geoffrey F. Strouse*

Cite This: *J. Phys. Chem. C* 2020, 124, 28220–28229

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Increasing Sn_{In}



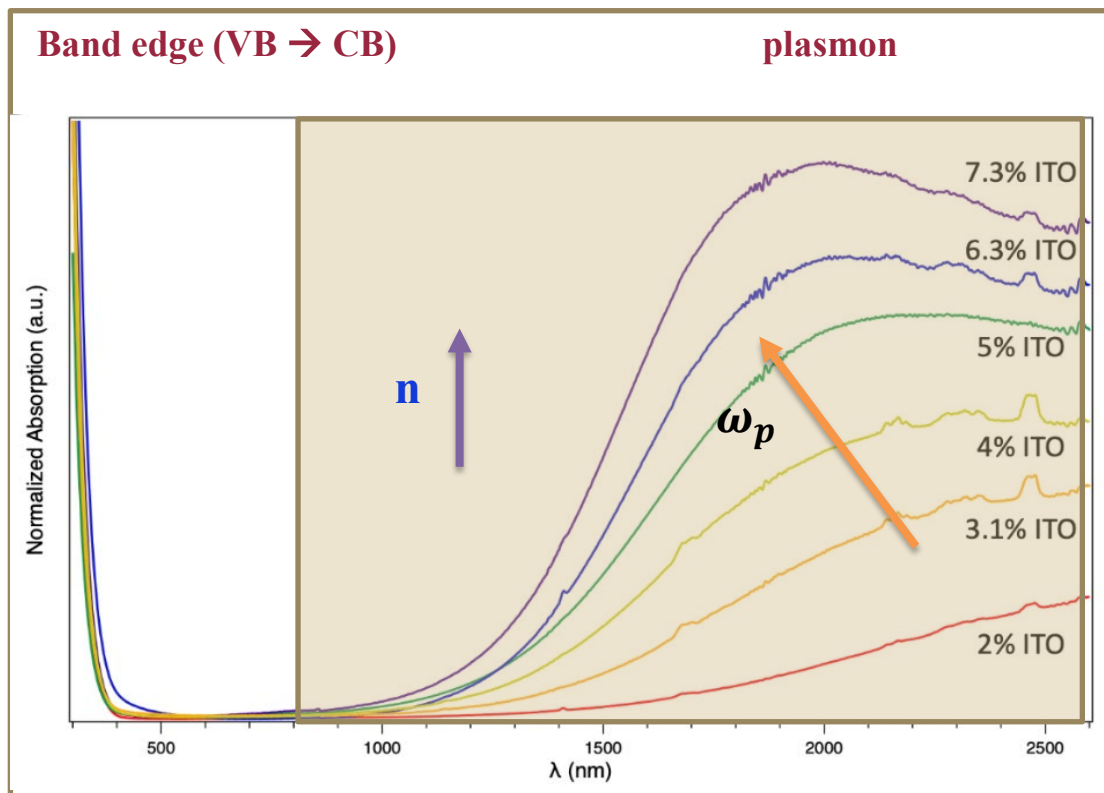


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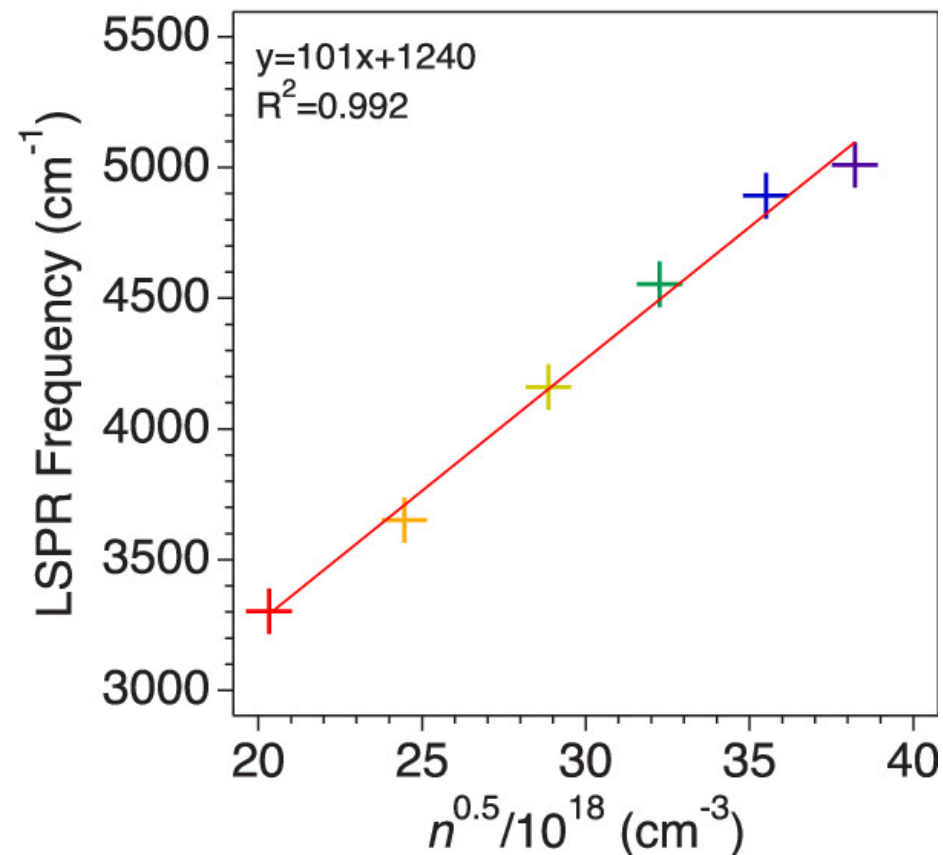
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(simplified)
The Drude Model

$$\omega_p^2 = \frac{n e^2}{m^* \epsilon_0}$$

b.



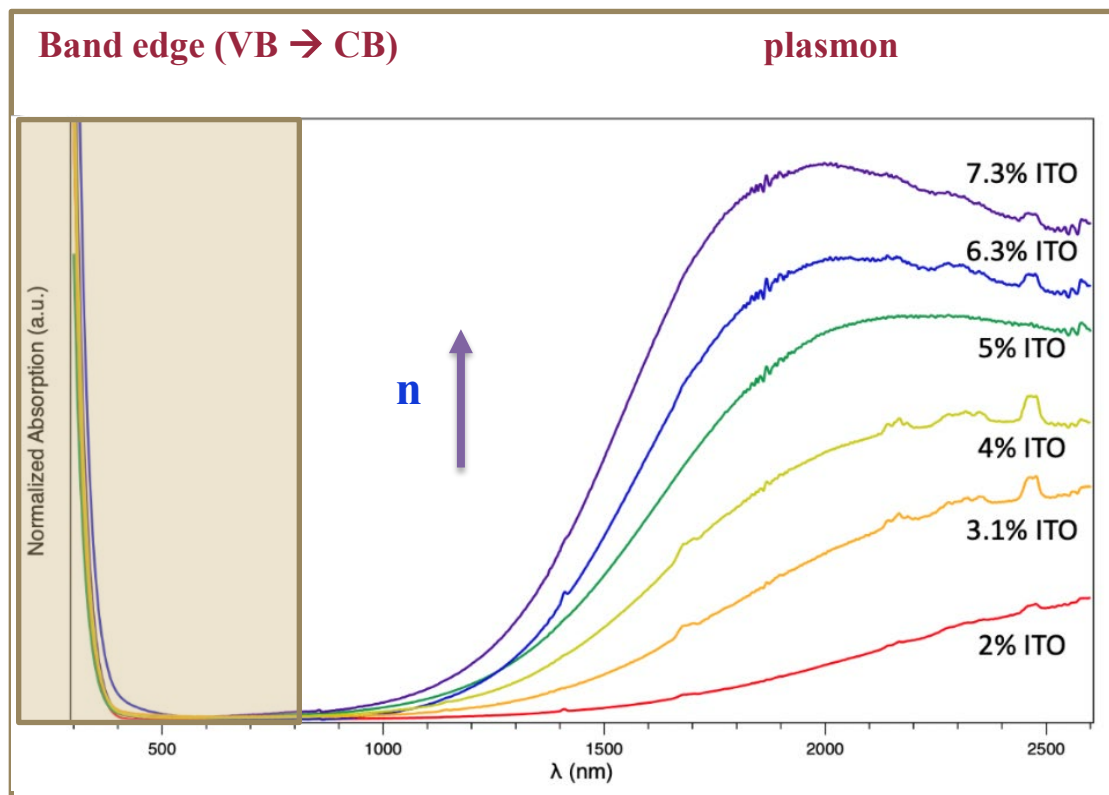


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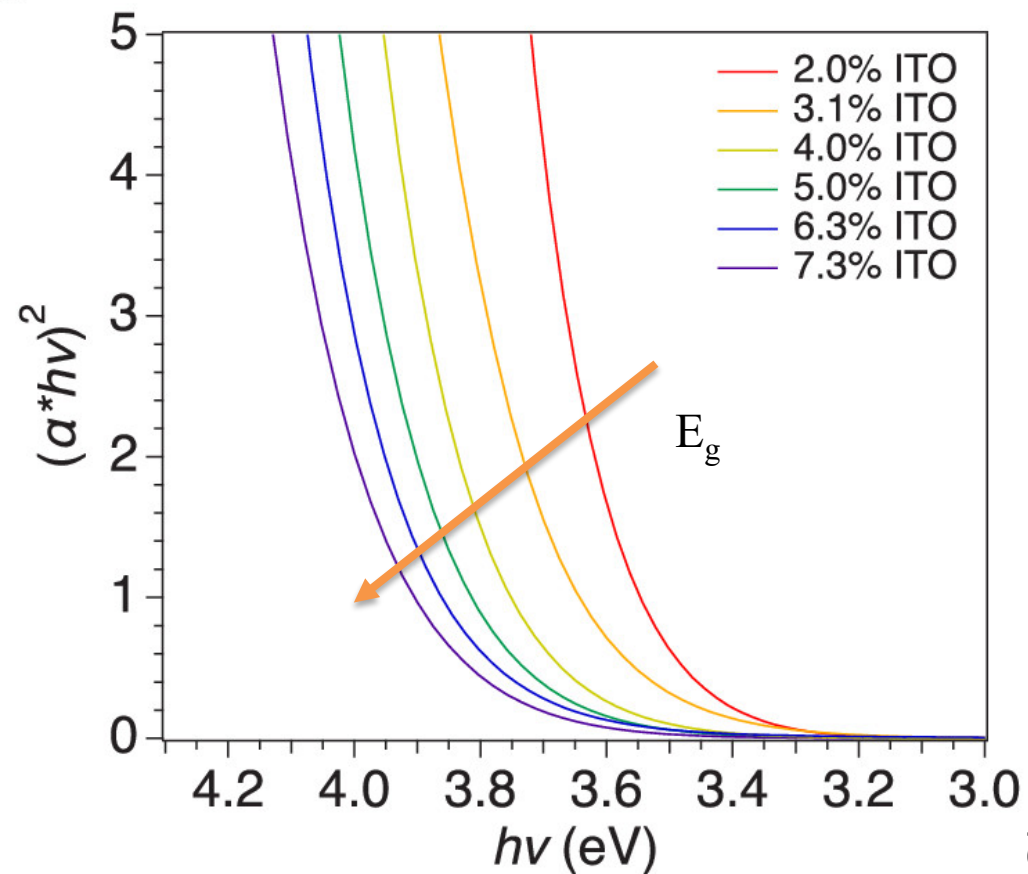
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Moss-Burstein (E_g)

$$\Delta E_{\text{abs}} = E_g^{\text{Sn}} - E_g^0 = \left(\frac{\hbar^2}{2m^*} \right) (3\pi^2 n)^{2/3}$$

a.



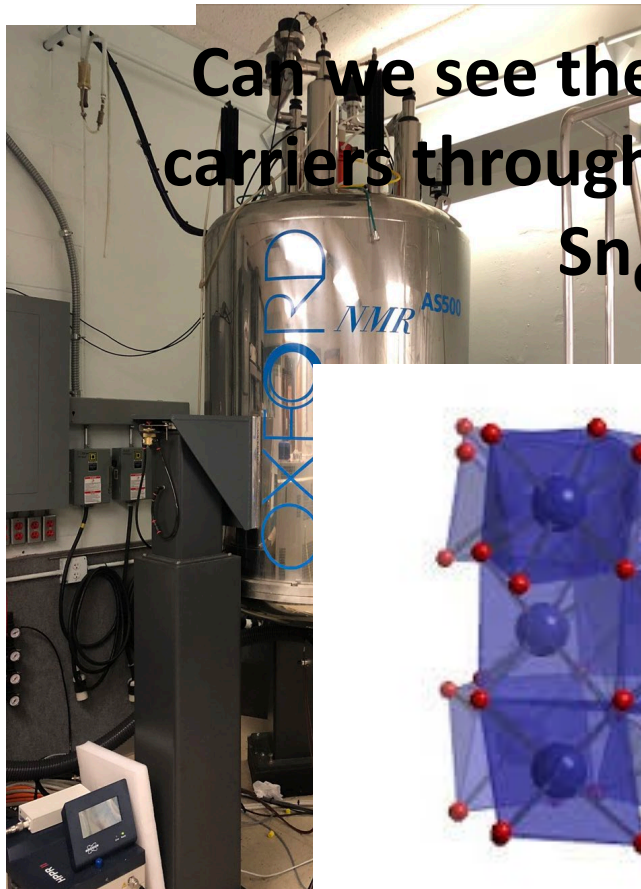
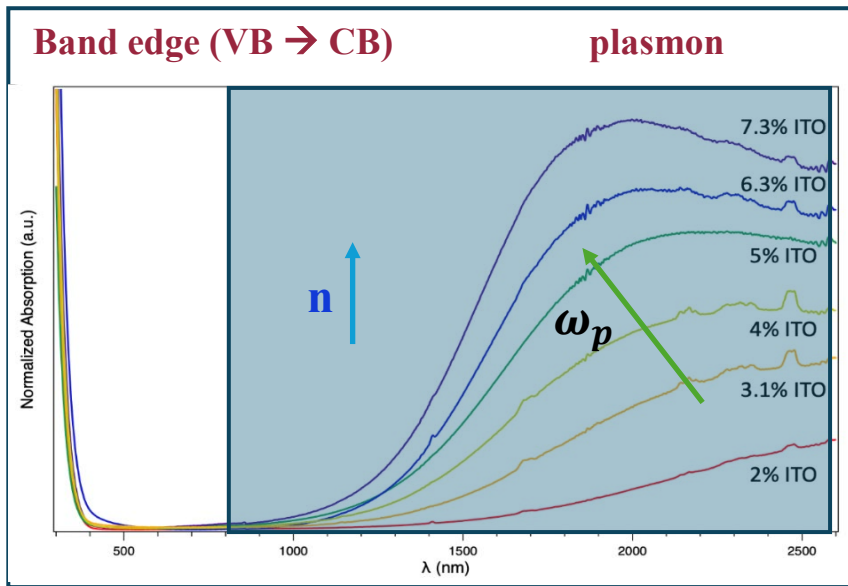
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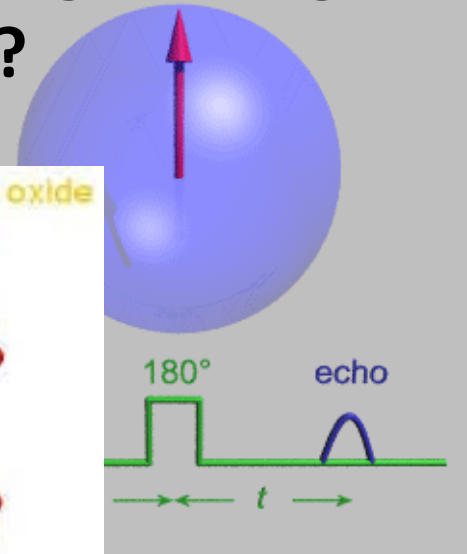
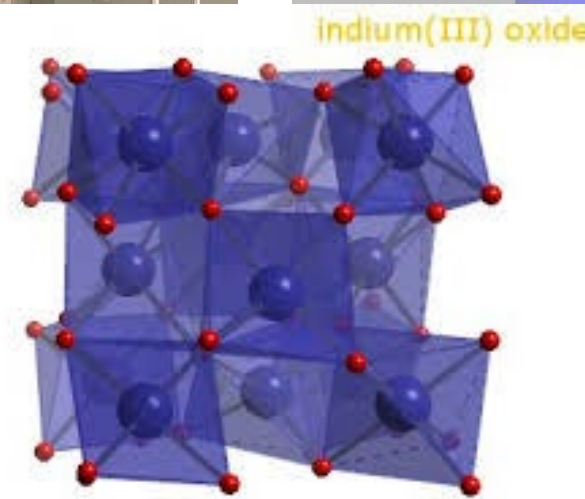
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¹¹⁹Sn MAS Solid-State NMR



Can we see the effect of introducing carriers through defect engineering of Sn_{Cd} on ITO?

Spin-Echo Experiment



.wikimedia.org/w/index.php

Bruker AVIII HD 500
MHz WB NMR



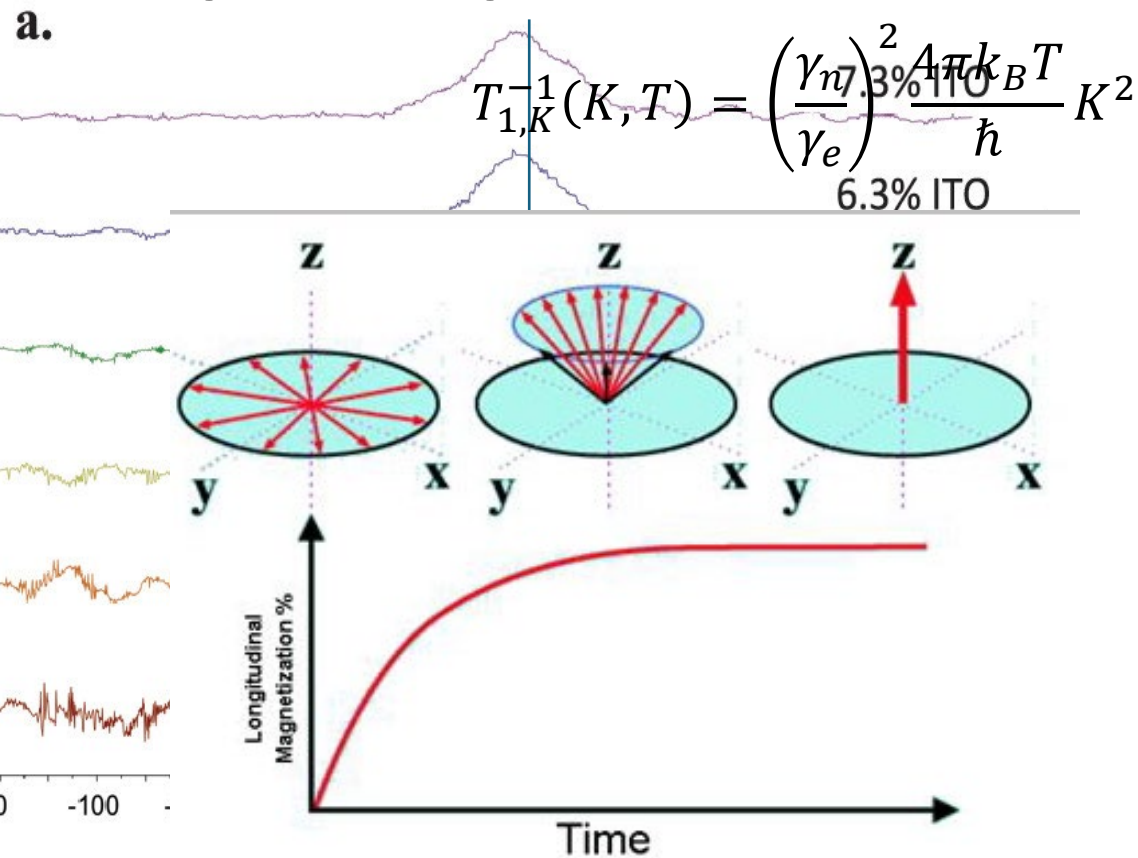
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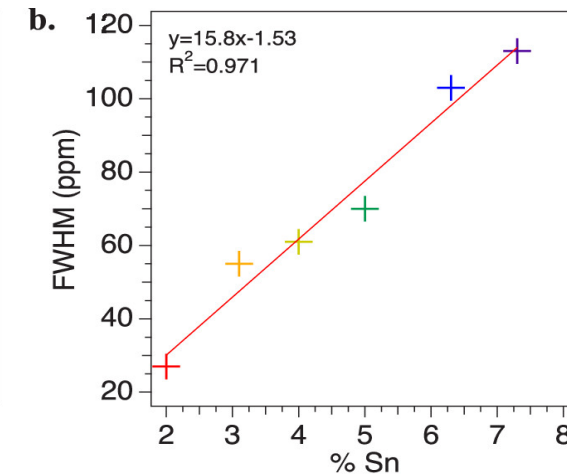
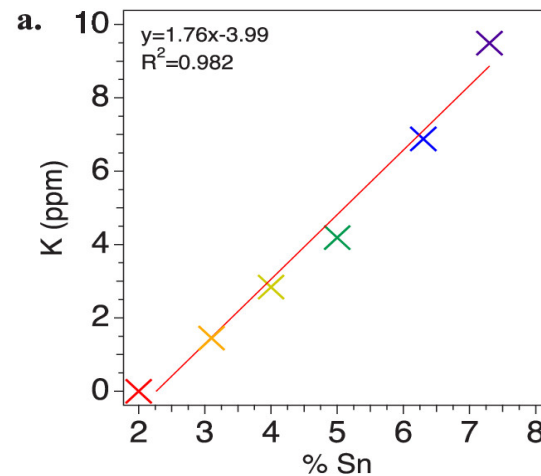
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¹¹⁹Sn MAS ssNMR spin-echo Knight-Korringa

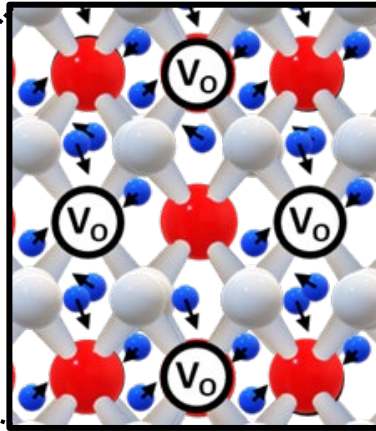
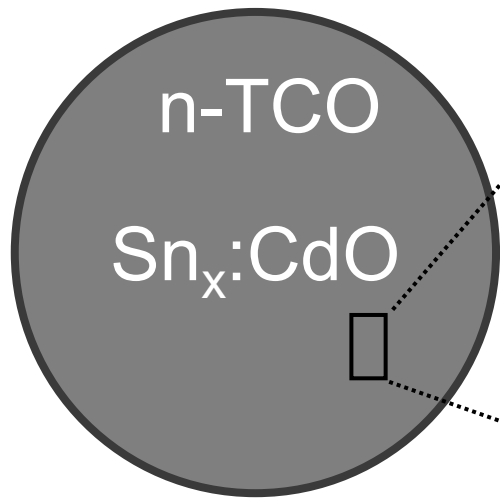


Knight shift ($\Delta\delta$)

FWHM ($\Delta\nu$)



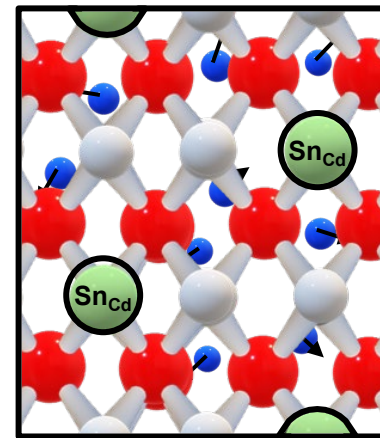
The ternary Cd – Sn – O PSNCs and the impact of structure on plasmonic properties



V_o Driven



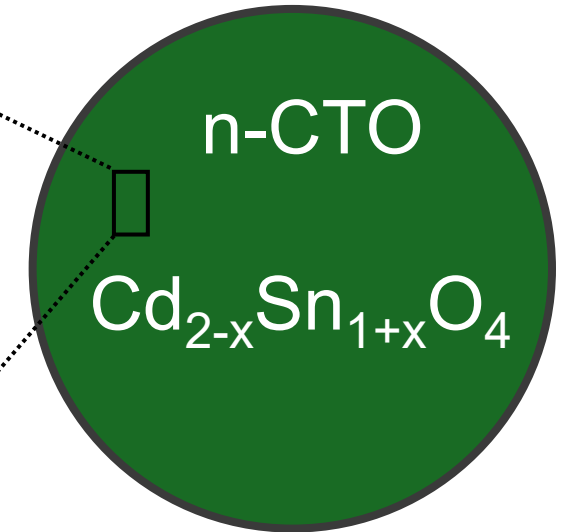
- Rock salt
- Sn(IV)
- V_o
- Carriers increase with x
- CdO = 0.26m_e

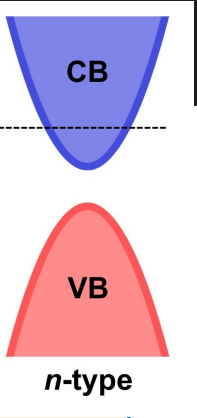


Sn_{Cd} Driven

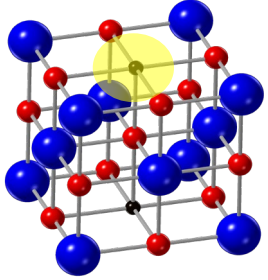


- Inverted spinel
- Sn(IV)
- Sn_{Cd}
- Carriers increase with x
- Cd_{1.86}Sn_{1.14}O₄ = 0.022m_e

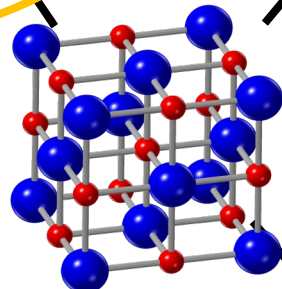
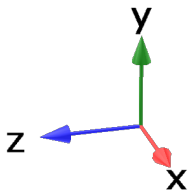
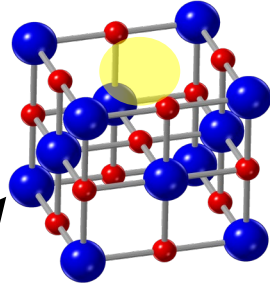




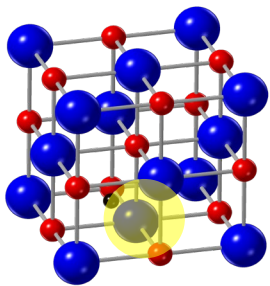
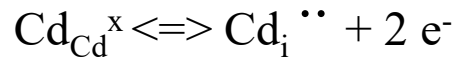
(antisite) $M1_{M2}$



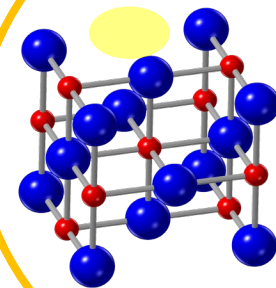
V_M



M_i



V_o



Defect Engineering

$V_{M/O}$,

M/O_i

$M2_{M1}$

carrier density

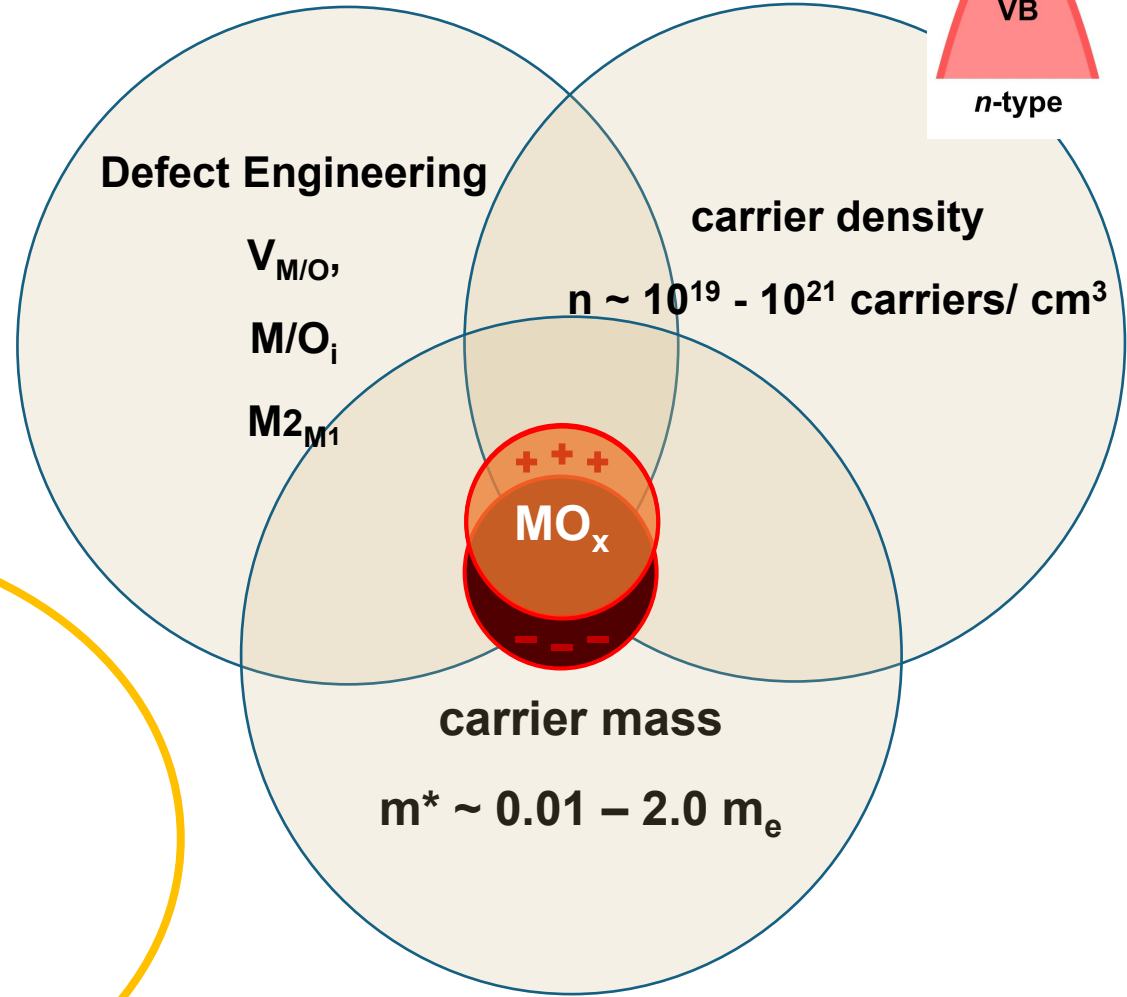
$n \sim 10^{19} - 10^{21} \text{ carriers/cm}^3$

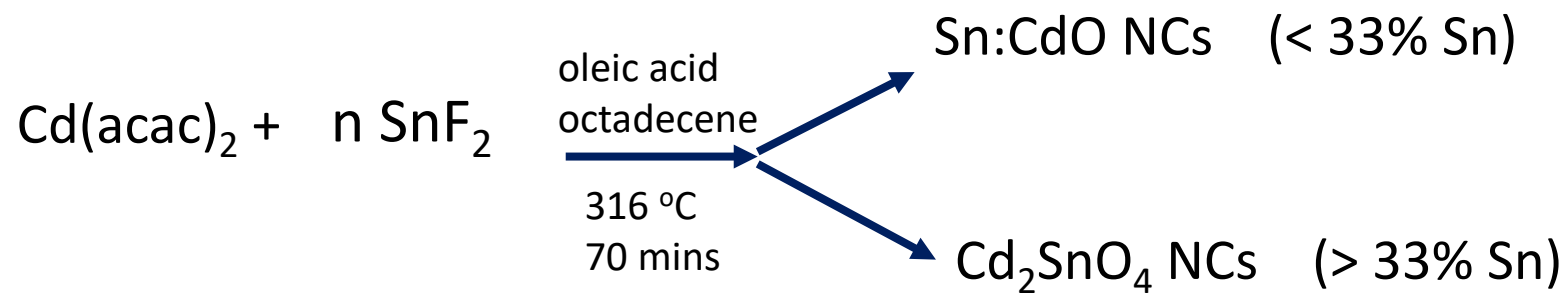
carrier mass

$m^* \sim 0.01 - 2.0 m_e$

MO_x

+++





Sn:CdO

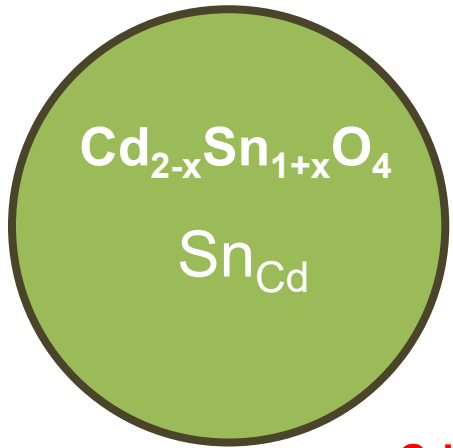
(V_o carriers)
Rock salt

vs.

Cd₂SnO₄

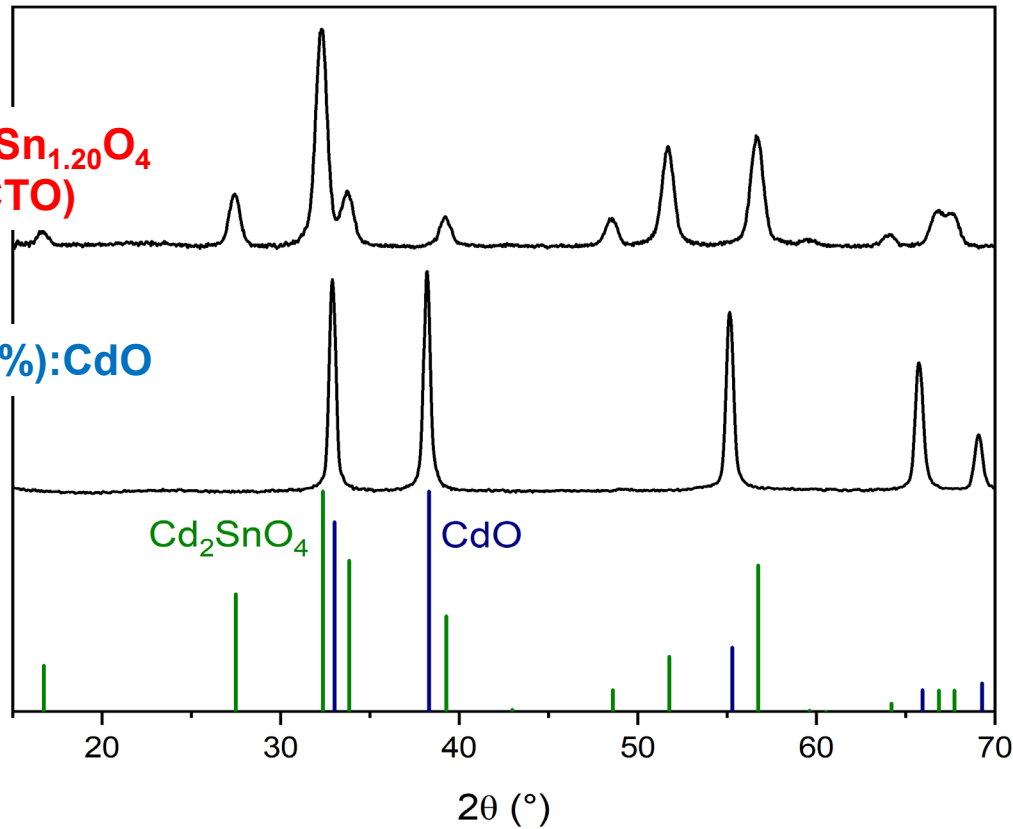
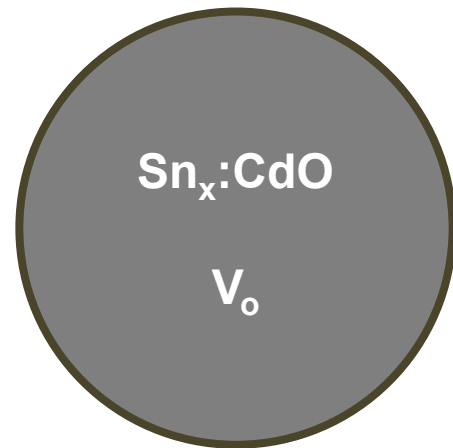
(antisite carriers)
inverted spinel



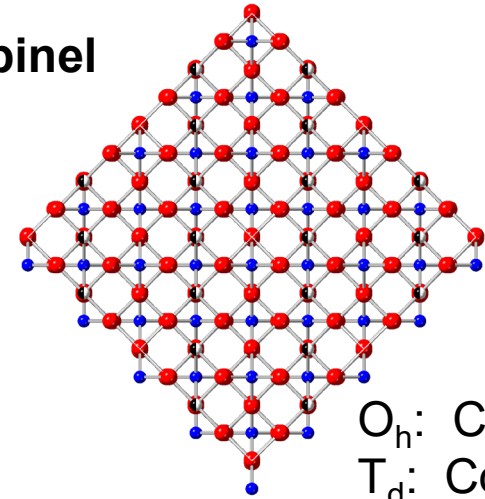


$Cd_{1.80}Sn_{1.20}O_4$
 (CTO)
 19 nm

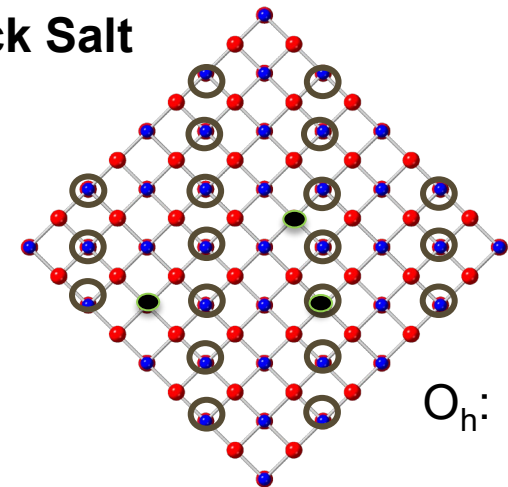
$Sn(10\%):CdO$
 21 nm

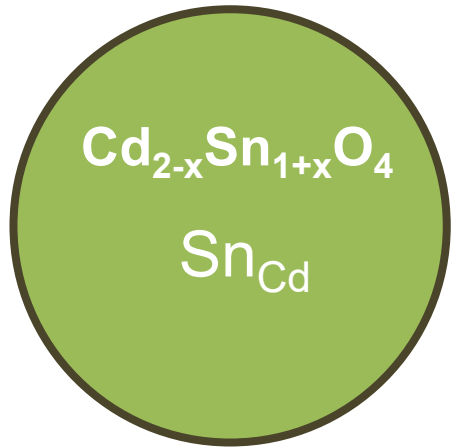


Inverted spinel



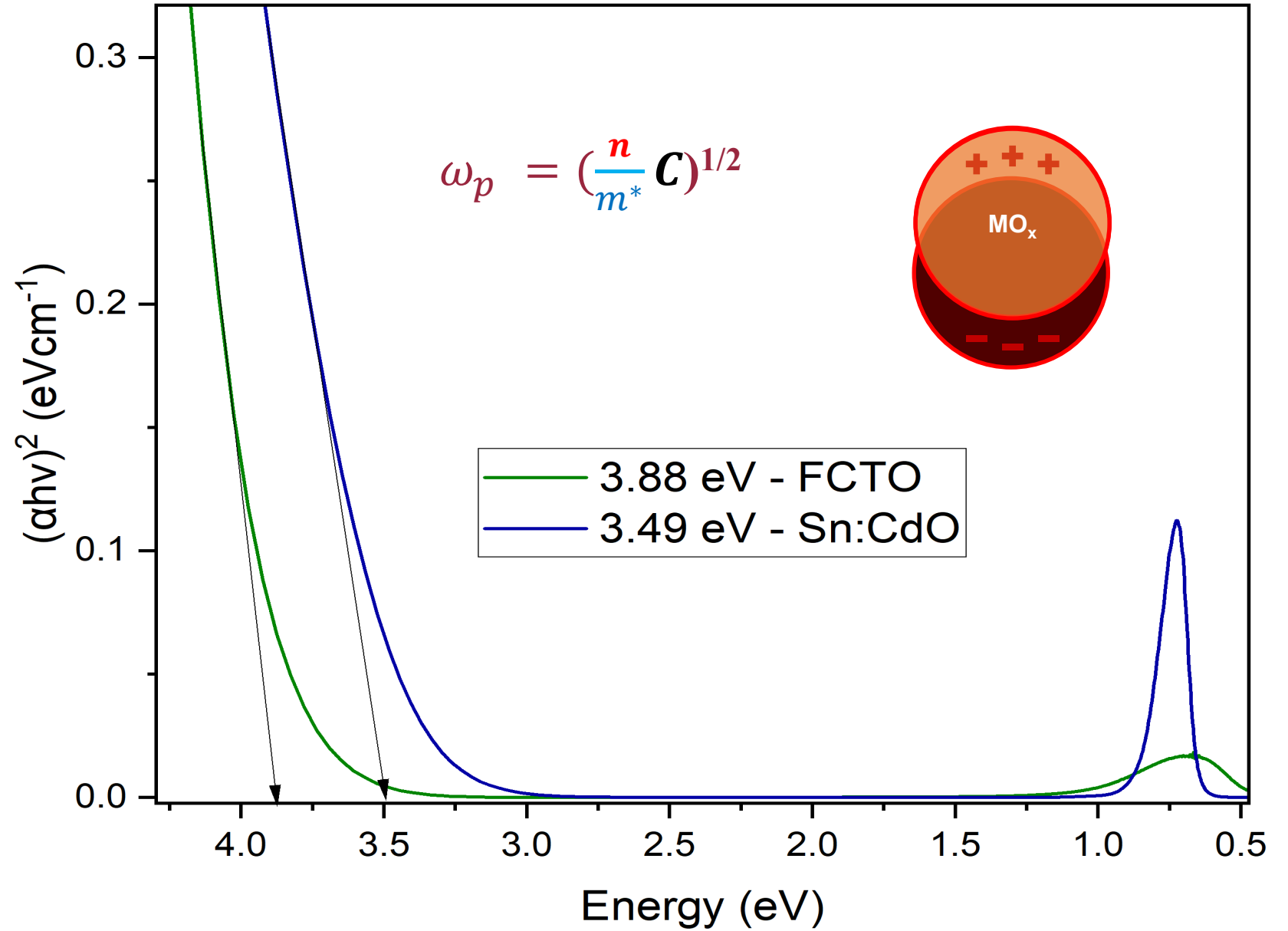
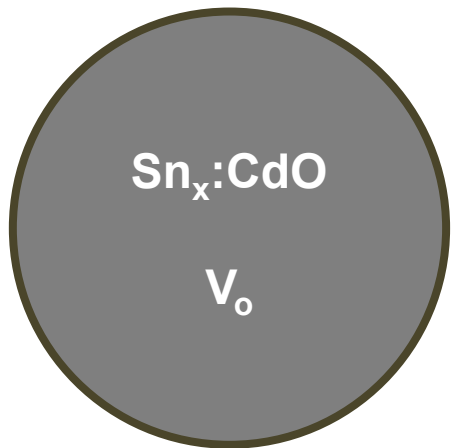
Rock Salt

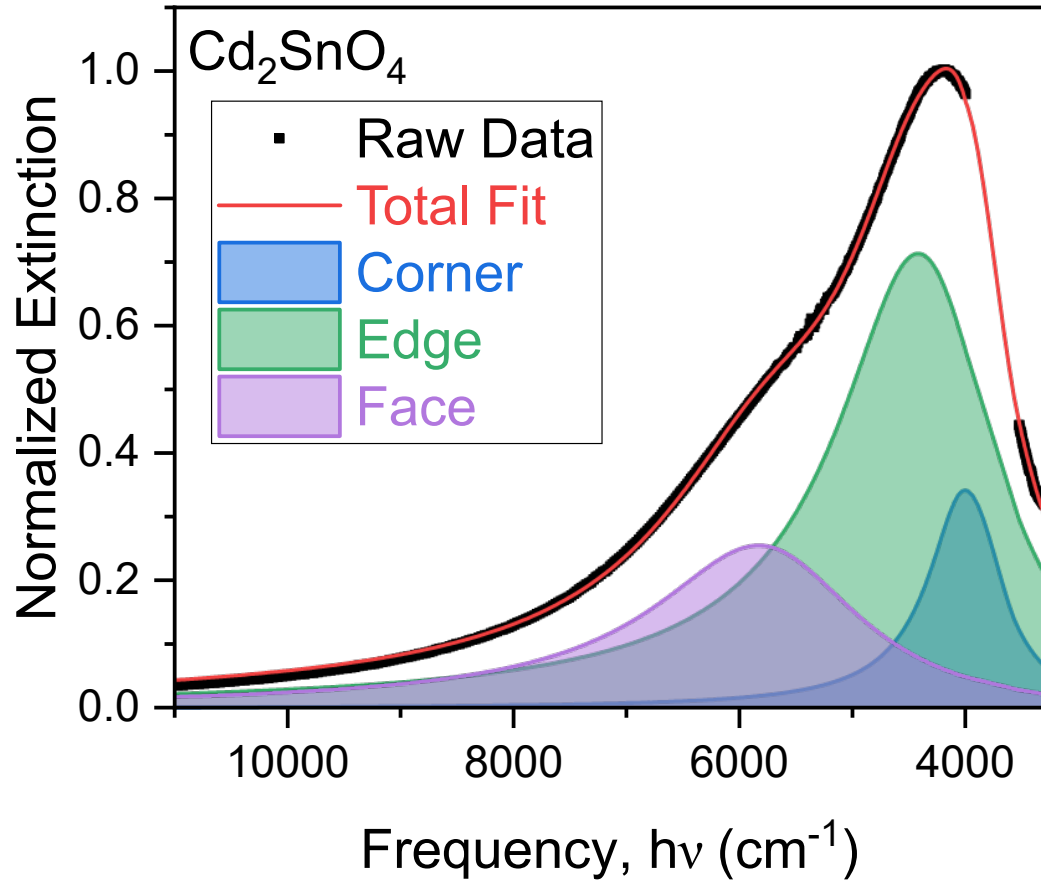
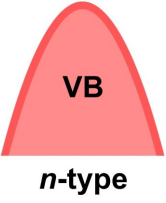
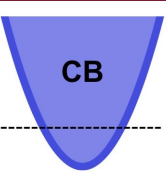




16 nm

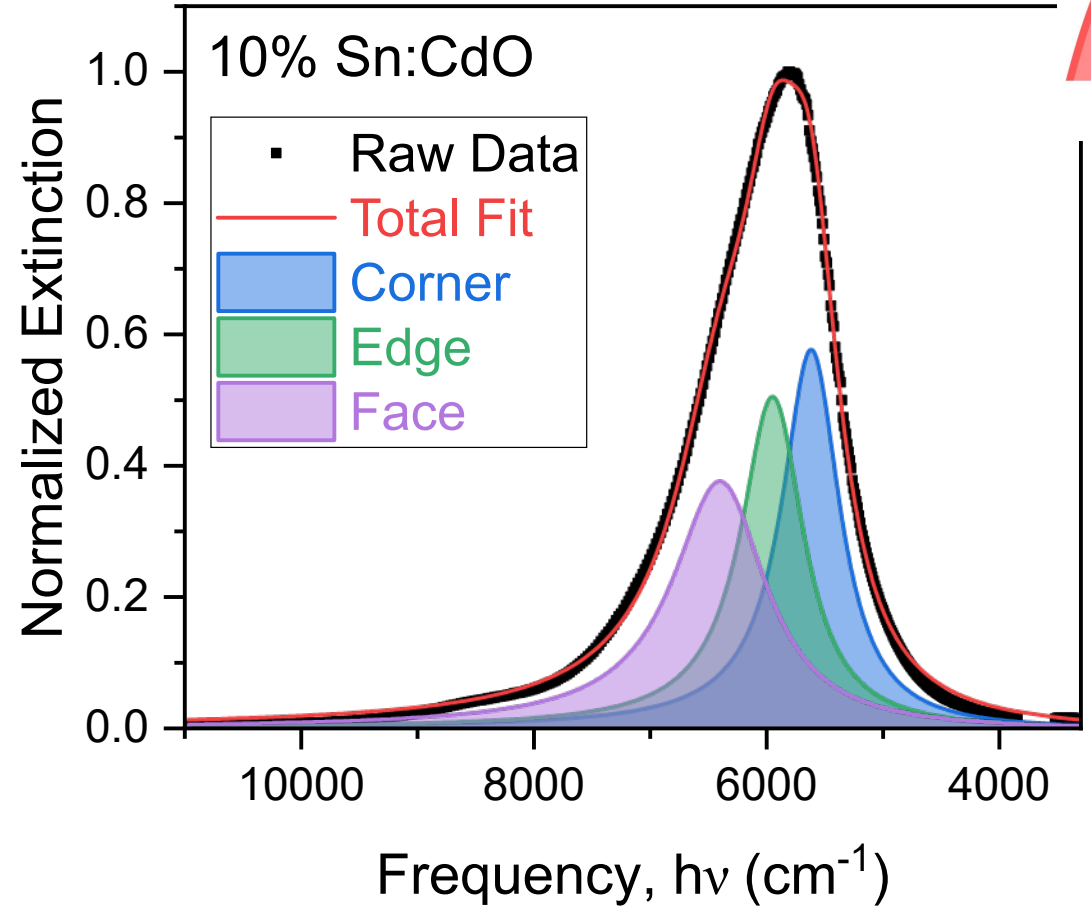
21 nm





$n = 5 \times 10^{19}$ carriers/cm³

$m^*(\text{Lit}) = 0.022m_e$



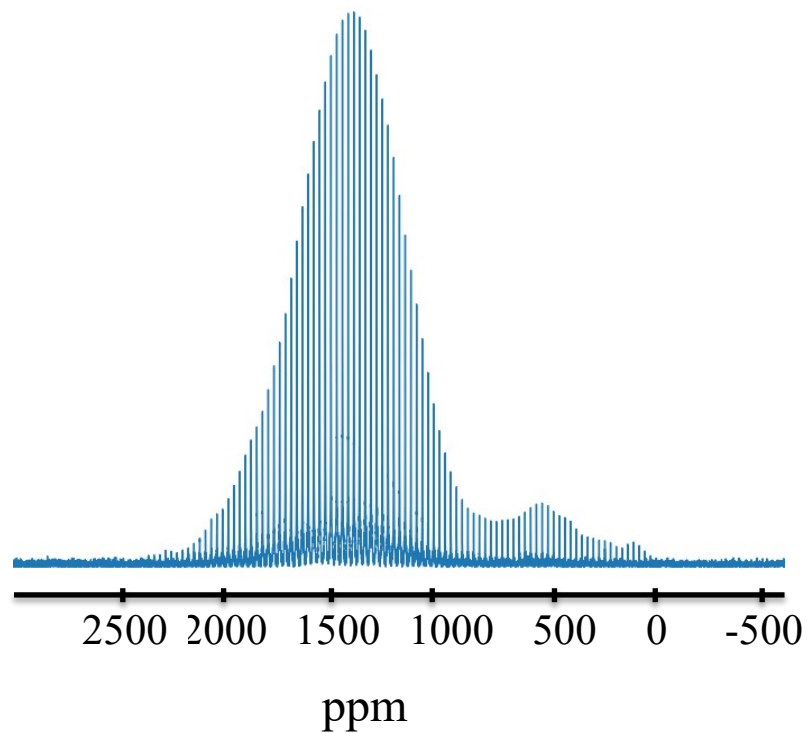
$n = 1.5 \times 10^{21}$ carriers/cm³

$m^*(\text{Lit}) = 0.26m_e$

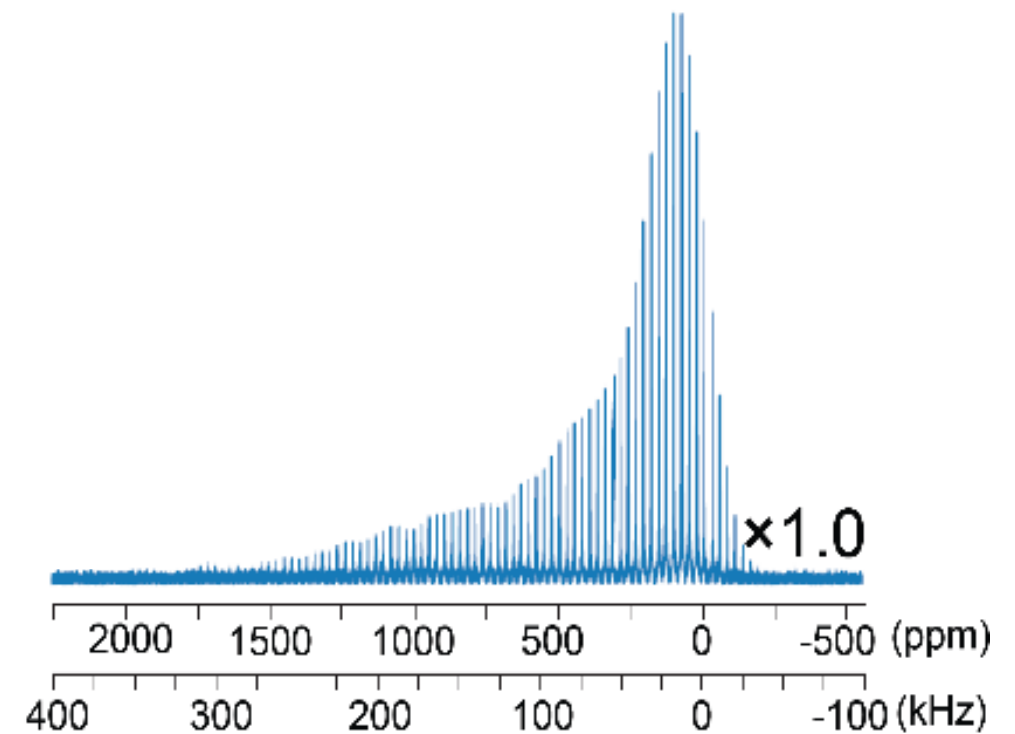


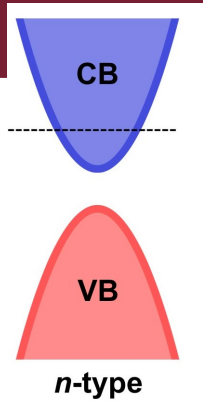
^{113}Cd solid state NMR to probe site dependent effect in Sn:CdO vs. CTO

^{113}Cd of 10% Sn:CdO PSNCs collected using a WURST-CPMG pulse sequence

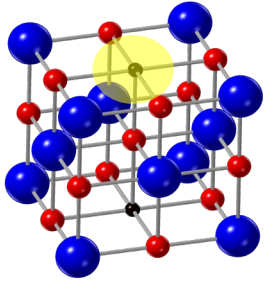


^{113}Cd of CTO PSNCs collected using a WURST-CPMG pulse sequence

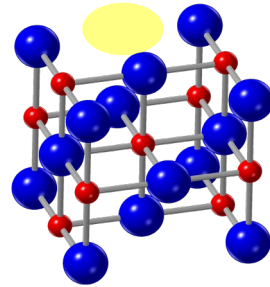




(antisite) Sn_{Cd}

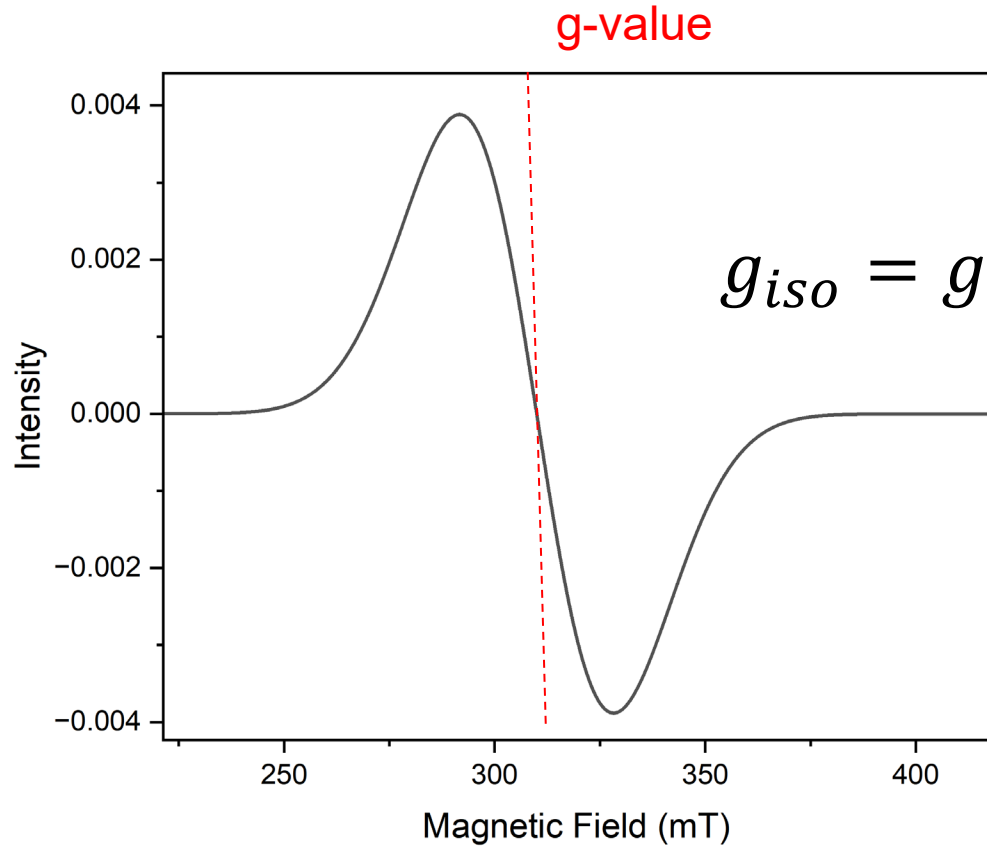
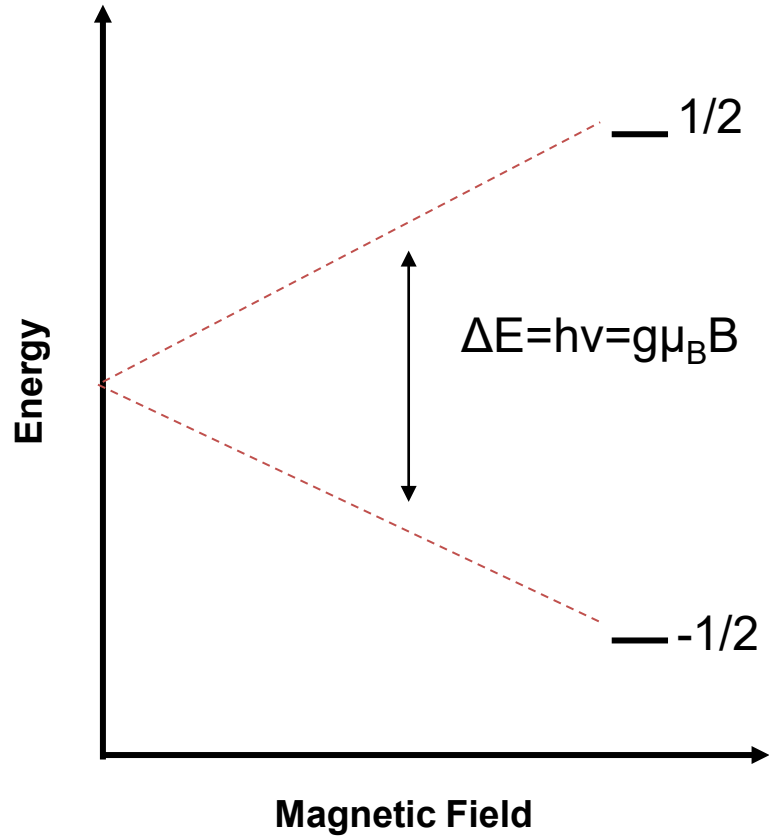


V_{O}



Are the carrier parentage really different?

Electron Paramagnetic Resonance (EPR)



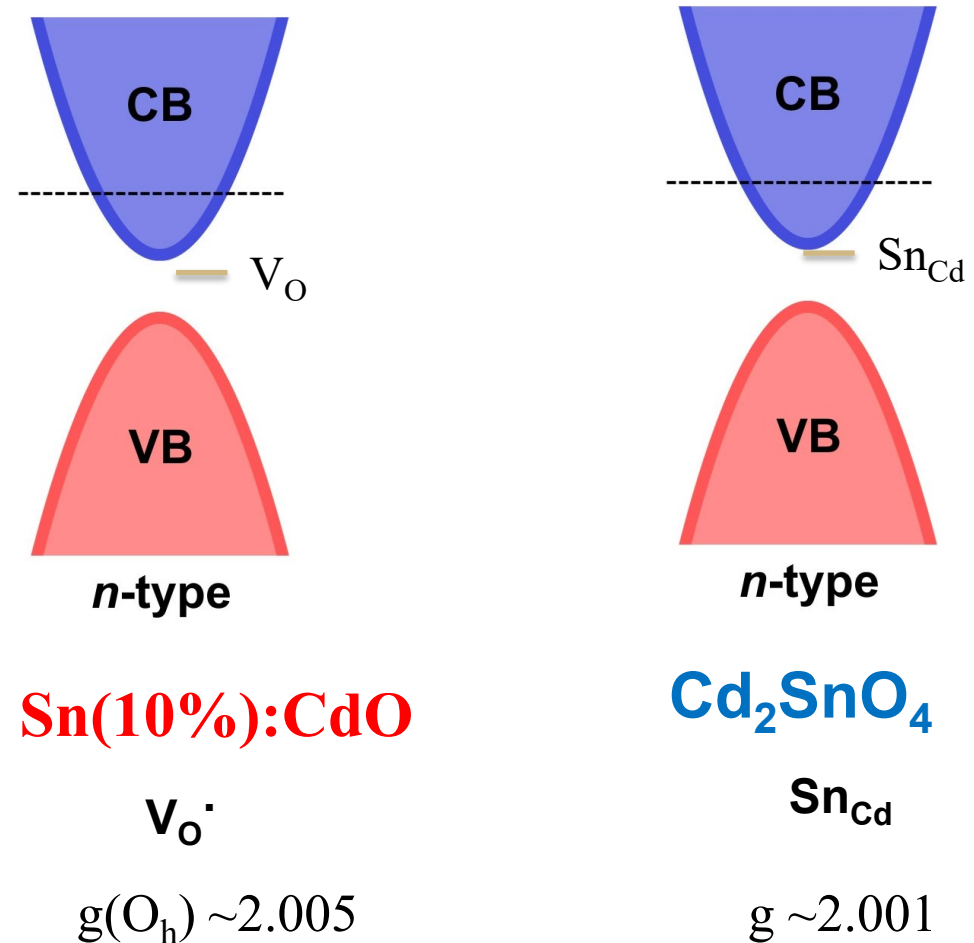
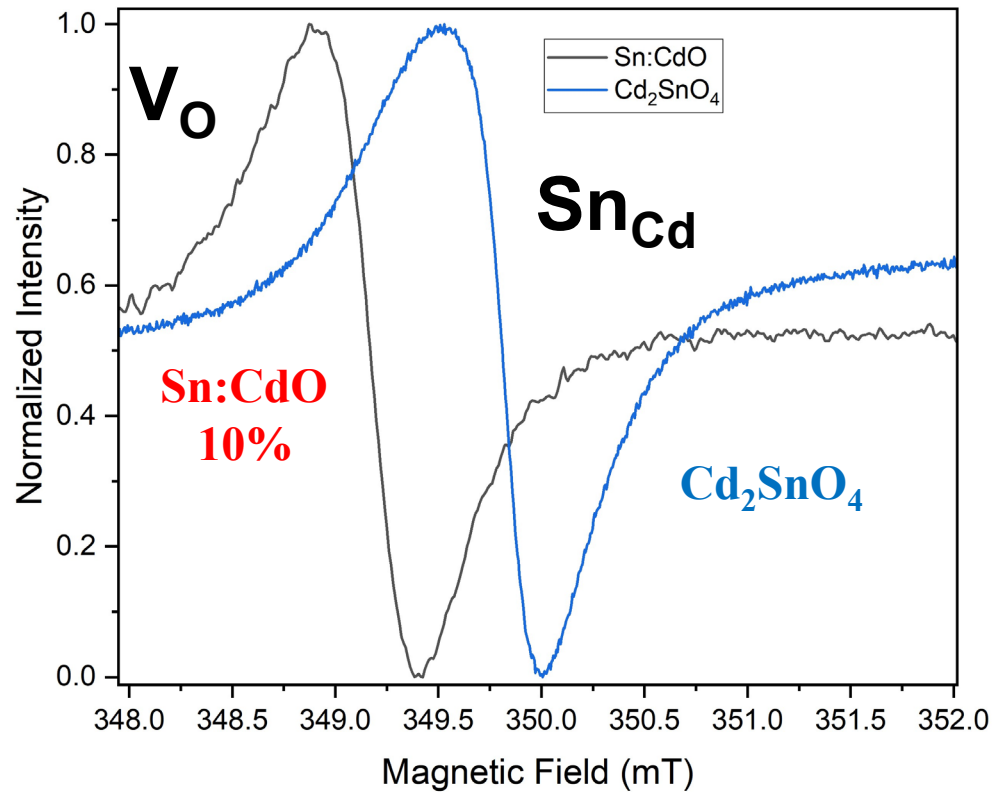
$$g_{iso} = g_e - \frac{2|\lambda|}{\sqrt{\lambda^2 + \Delta^2}}$$

λ = spin-orbit coupling
 Δ = crystal field



Identifying the defect type by EPR

(X-band, RT)

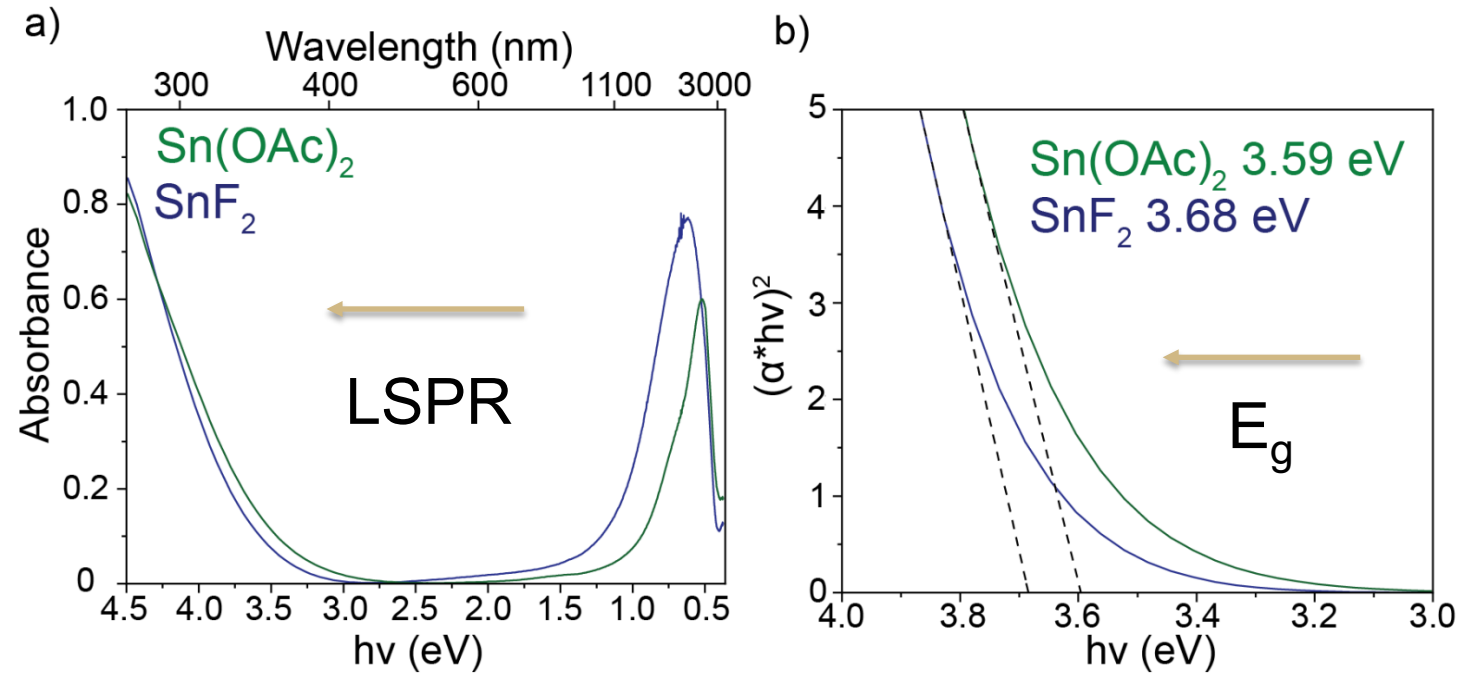
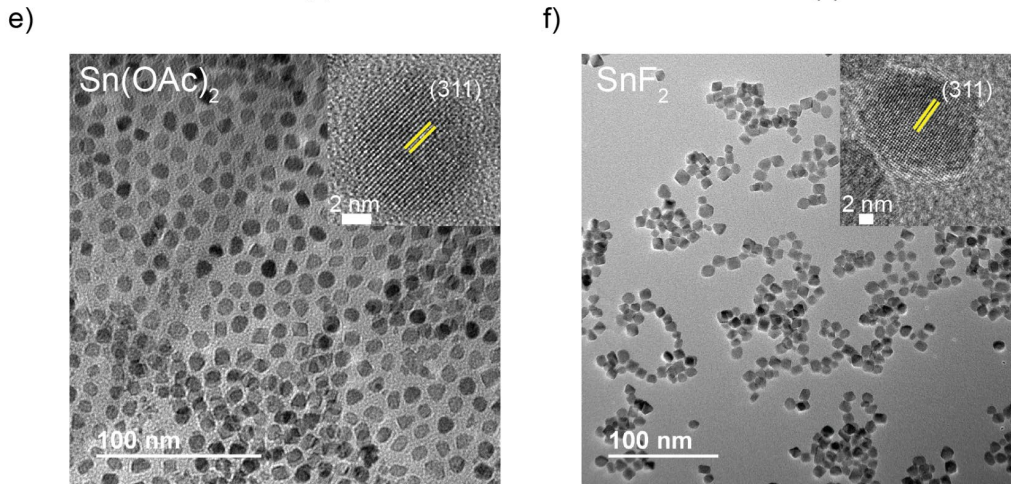
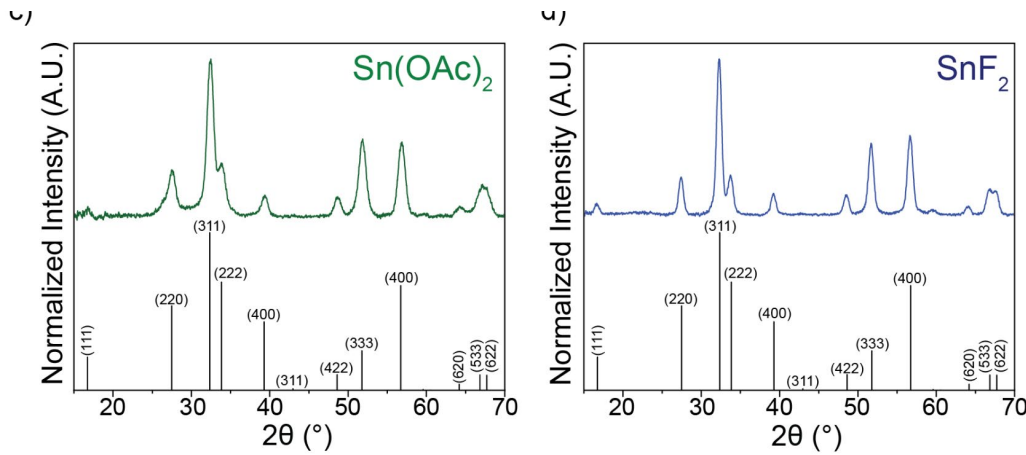


CdO Liu, Z. et al., ACS Nano., 2020

ZnO Ayoub, I. et al., Nanotechnol. Rev., 2022

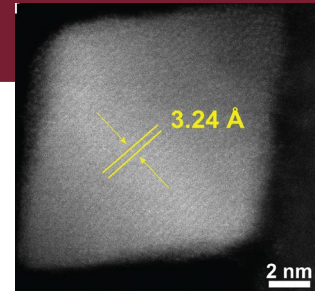
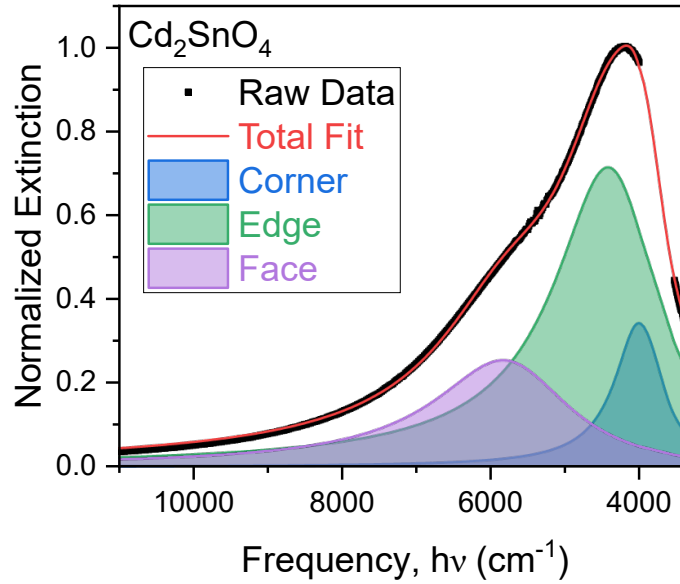


Can we increase carrier densities by removal of V_o (Oxygen vacancy) by active etching using SnF_2 as reactant instead of $\text{Sn}(\text{acac})_2$?



$$\omega_p^2 = \frac{ne^2}{m^*\epsilon_0} = \frac{n}{m^*} C$$

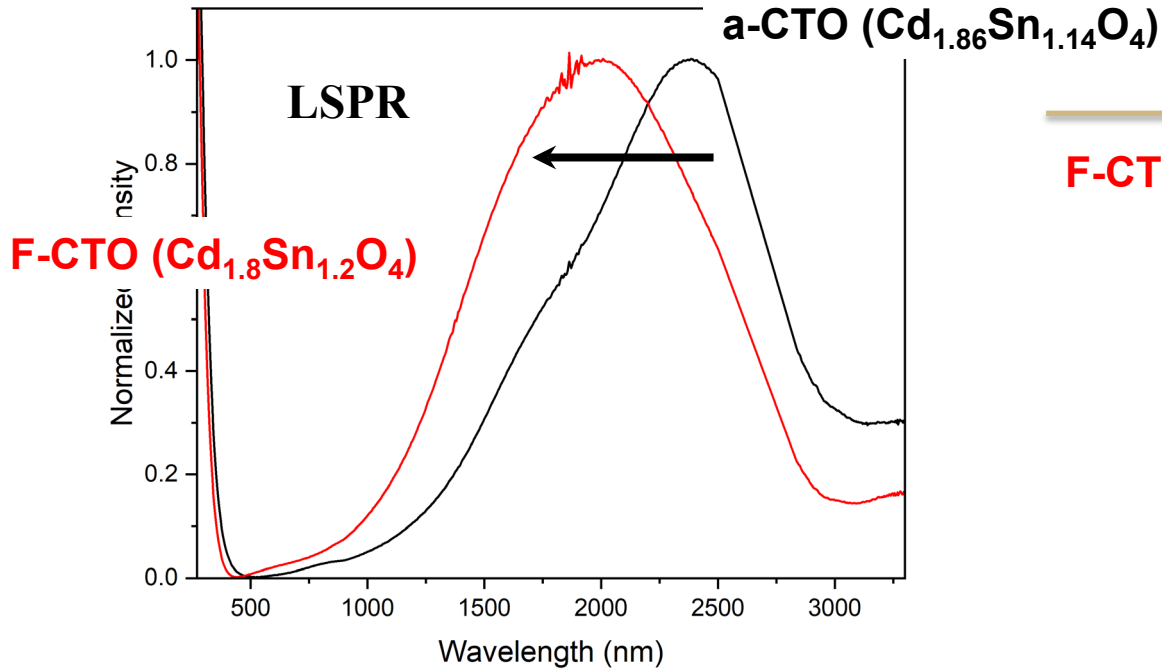
a-CTO ($Cd_{1.86}Sn_{1.14}O_4$)



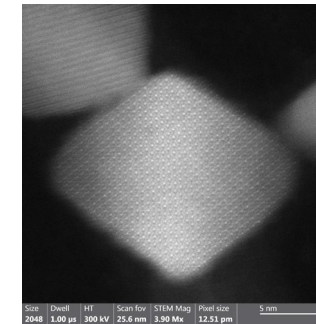
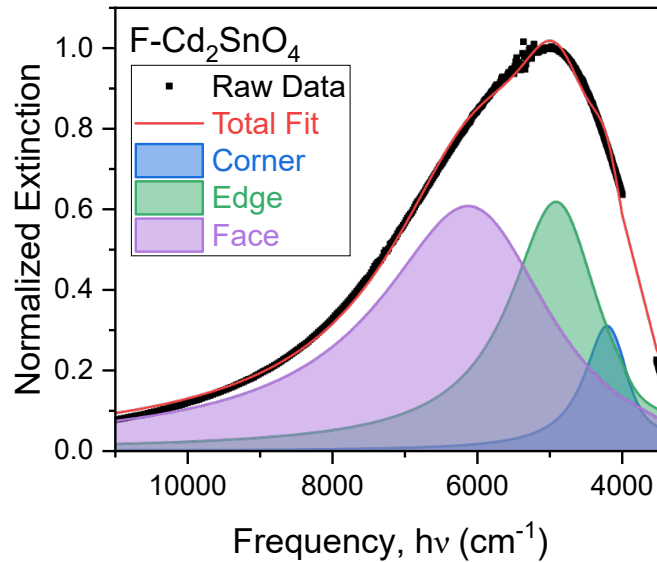
19 x 14 nm

Aspect ratio: 1.36

$n = 5 \times 10^{19}$ carriers/cm³



F-CTO ($Cd_{1.8}Sn_{1.2}O_4$)



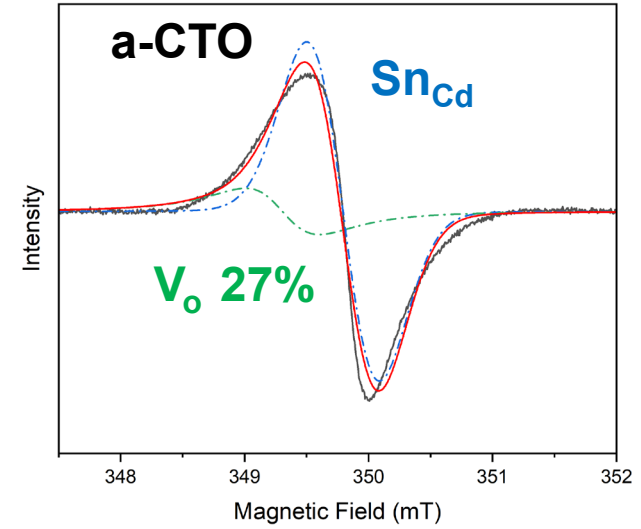
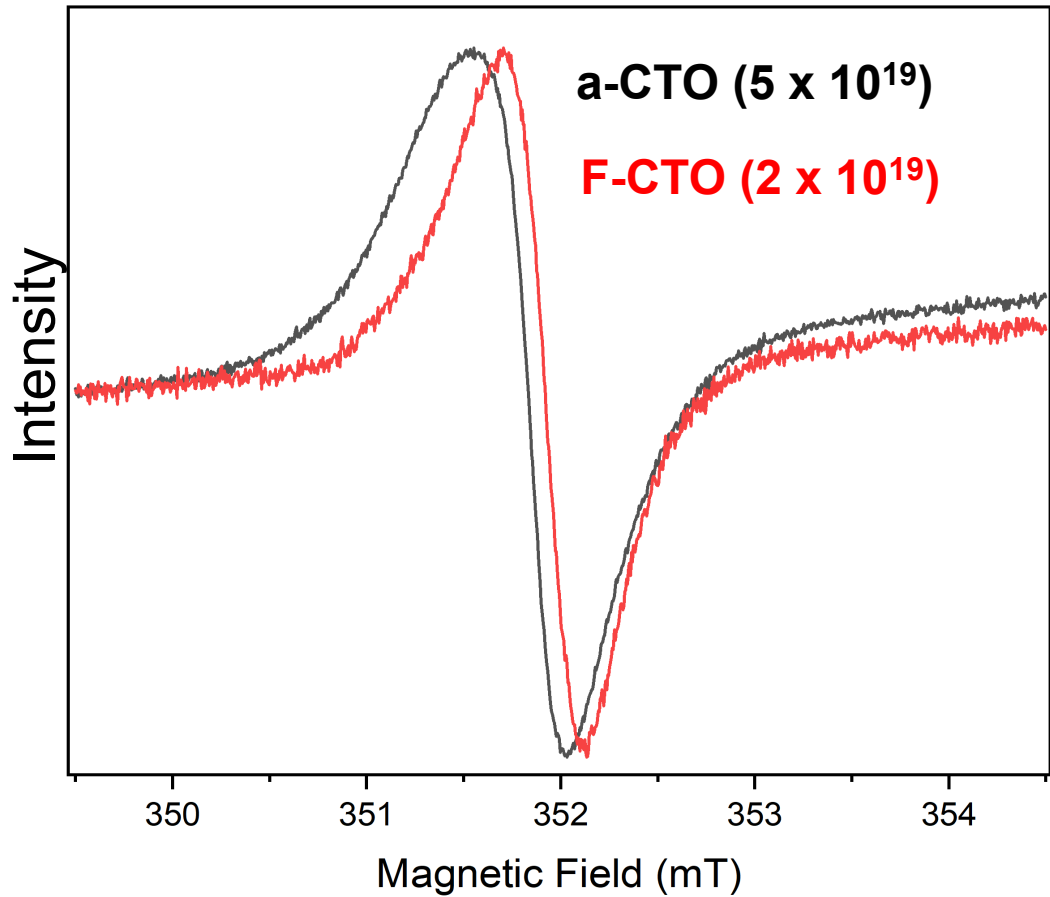
22 x 18 nm

Aspect ratio: 1.22

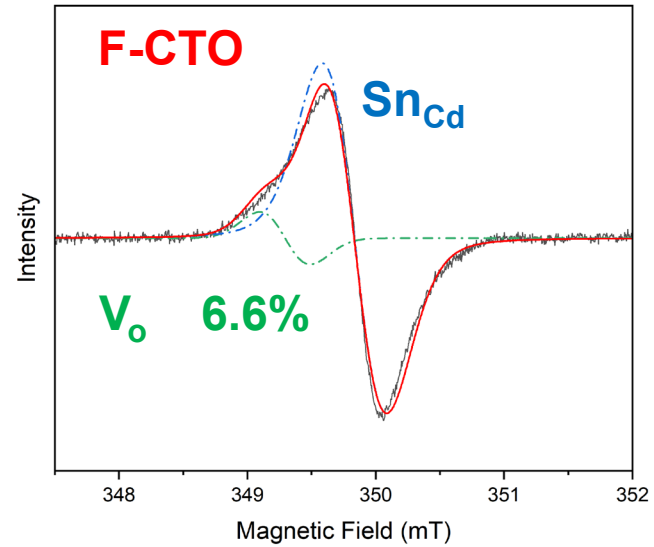
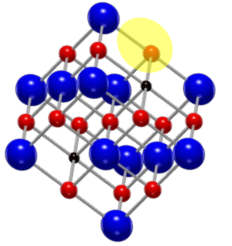
$n = 2 \times 10^{19}$ carriers/cm³



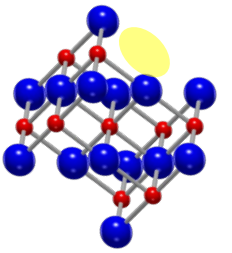
Does EPR help us understand?



Sn_{Cd}
 $g \sim 2.001$



V_O[•]
 $g(O_h) \sim 2.005$



EPR confirms lower V_O for F-CTO, but why no increase in n ?

^{113}Cd – WURST

FCTO

$\Gamma(\text{KS}) = 450\text{KHz}$

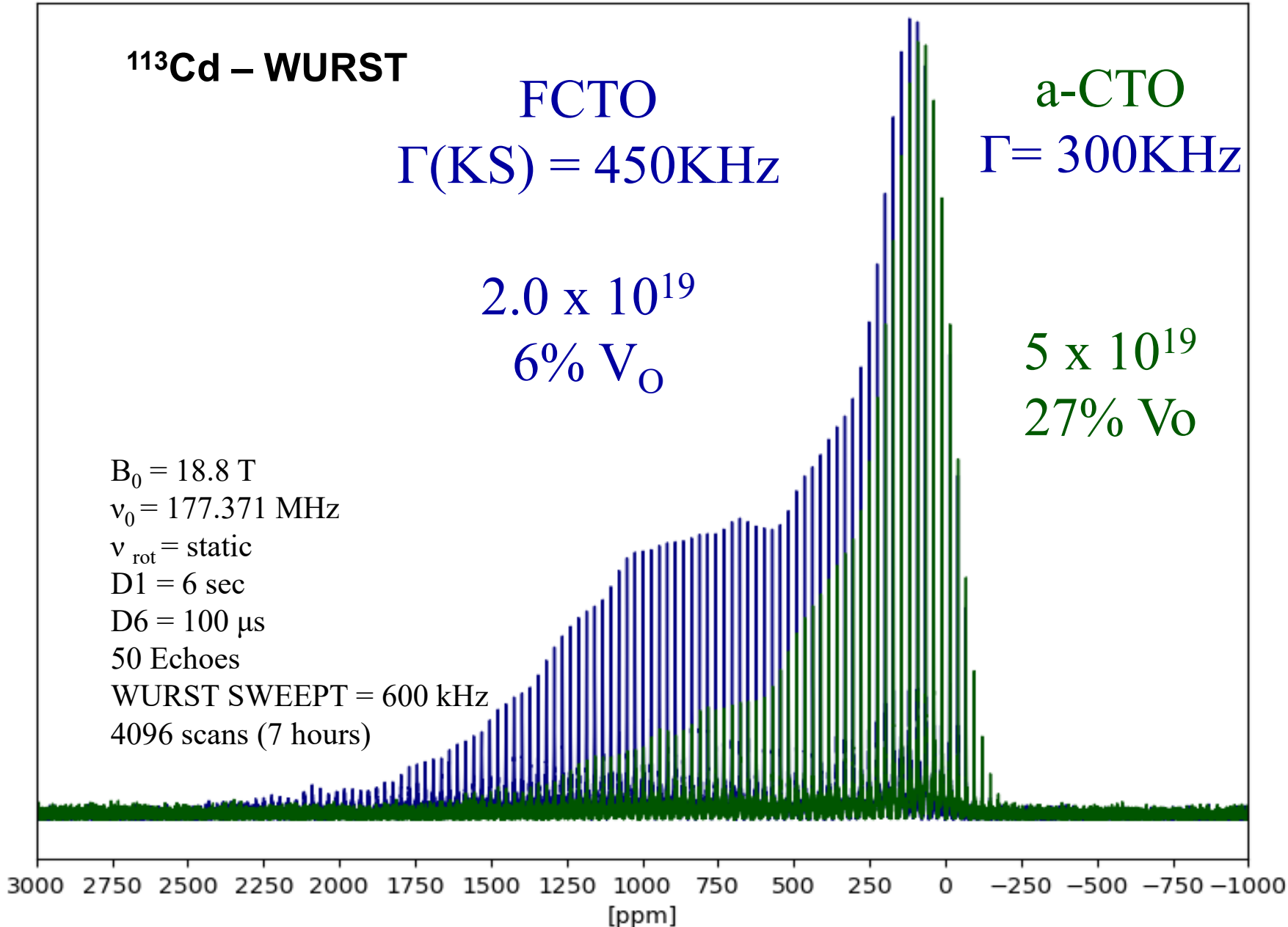
2.0×10^{19}
 $6\% V_o$

a-CTO

$\Gamma = 300\text{KHz}$

5×10^{19}
 $27\% V_o$

$B_0 = 18.8\text{ T}$
 $\nu_0 = 177.371\text{ MHz}$
 $\nu_{\text{rot}} = \text{static}$
 $D1 = 6\text{ sec}$
 $D6 = 100\ \mu\text{s}$
50 Echoes
WURST SWEEP = 600 kHz
4096 scans (7 hours)



Observe a large increase in Knight Shift (KS)

$$KS \propto n^{1/3}$$

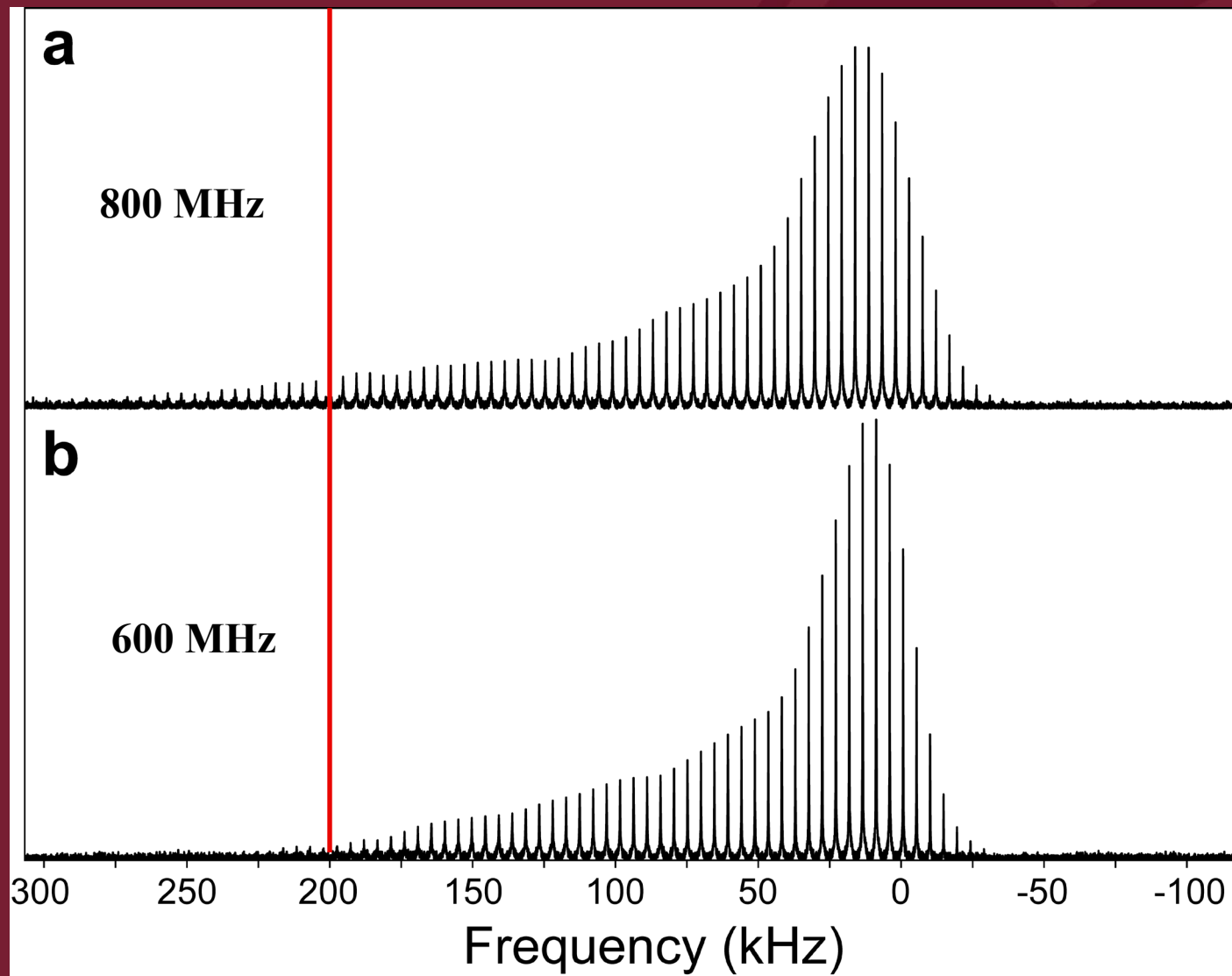
FCTO has lower carrier density but also lower V_o

Slower relaxation, T_1
Knight-Korringa



FLORIDA STATE
UNIVERSITY

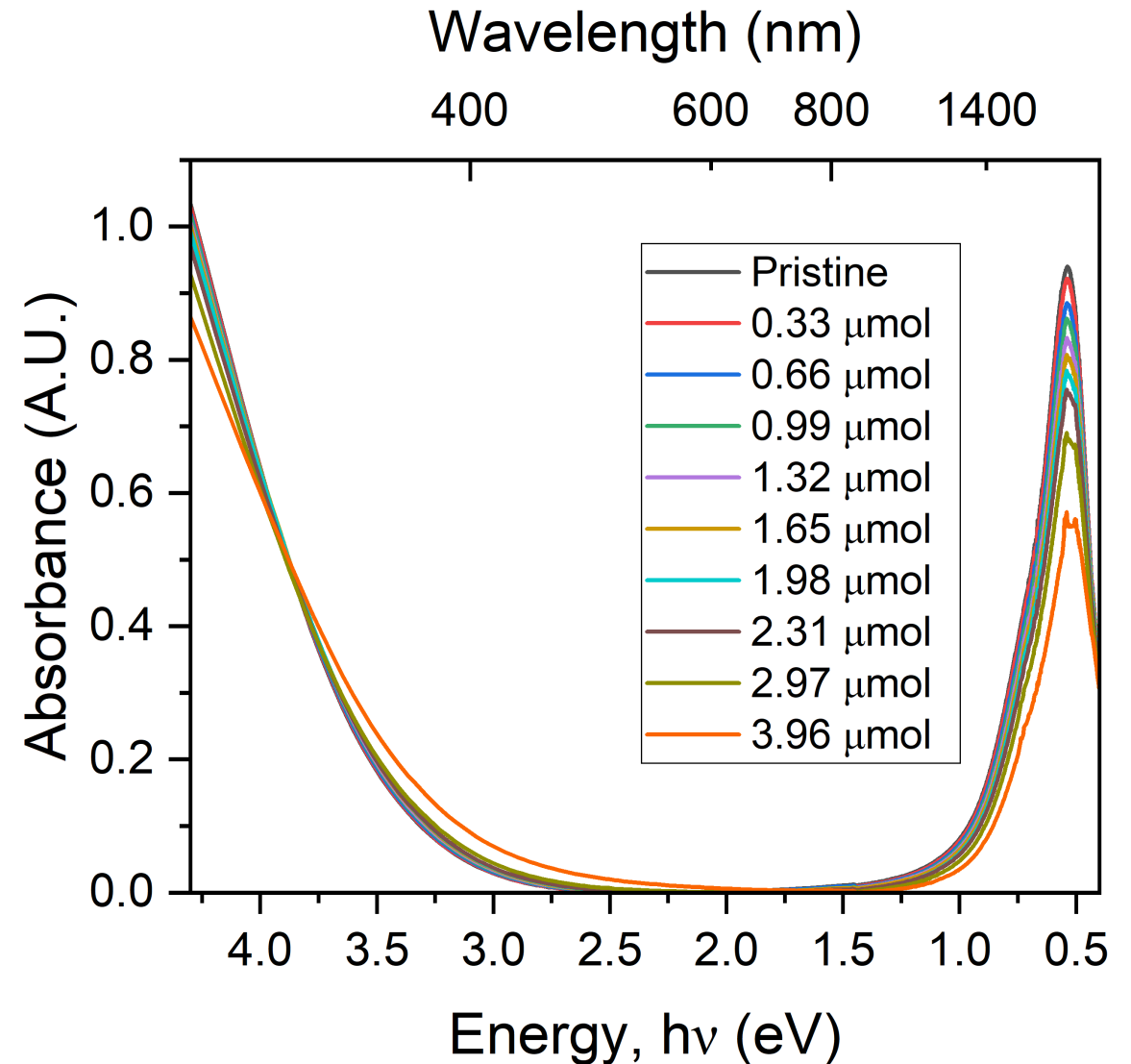
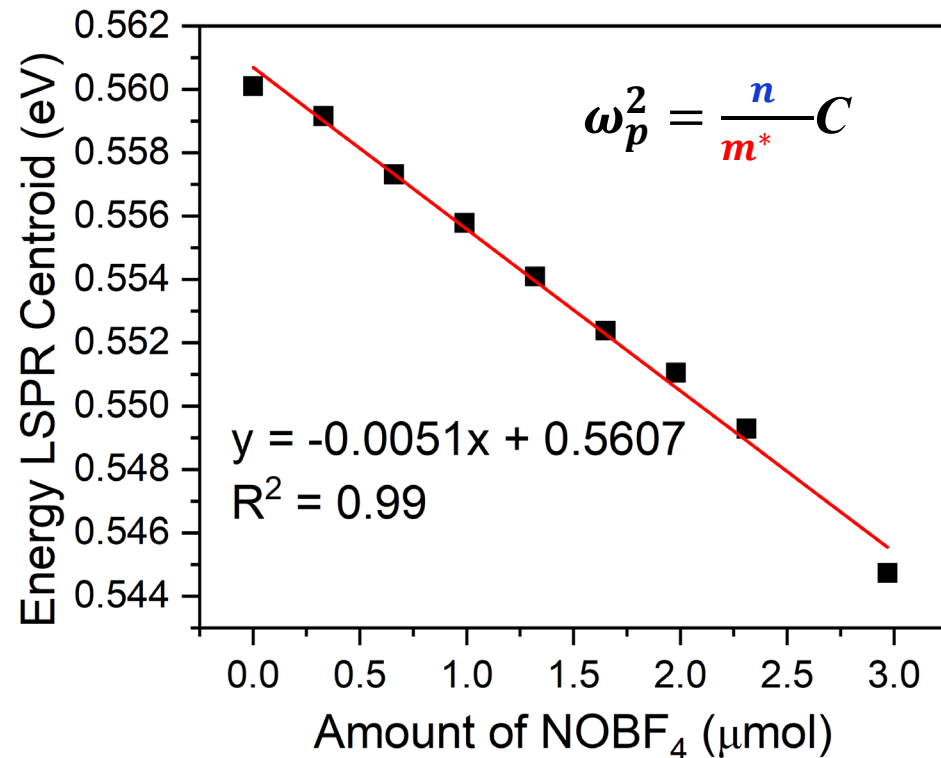
But are we sure its KS and not CS?



KS frequency shift
will be dependent
on applied field



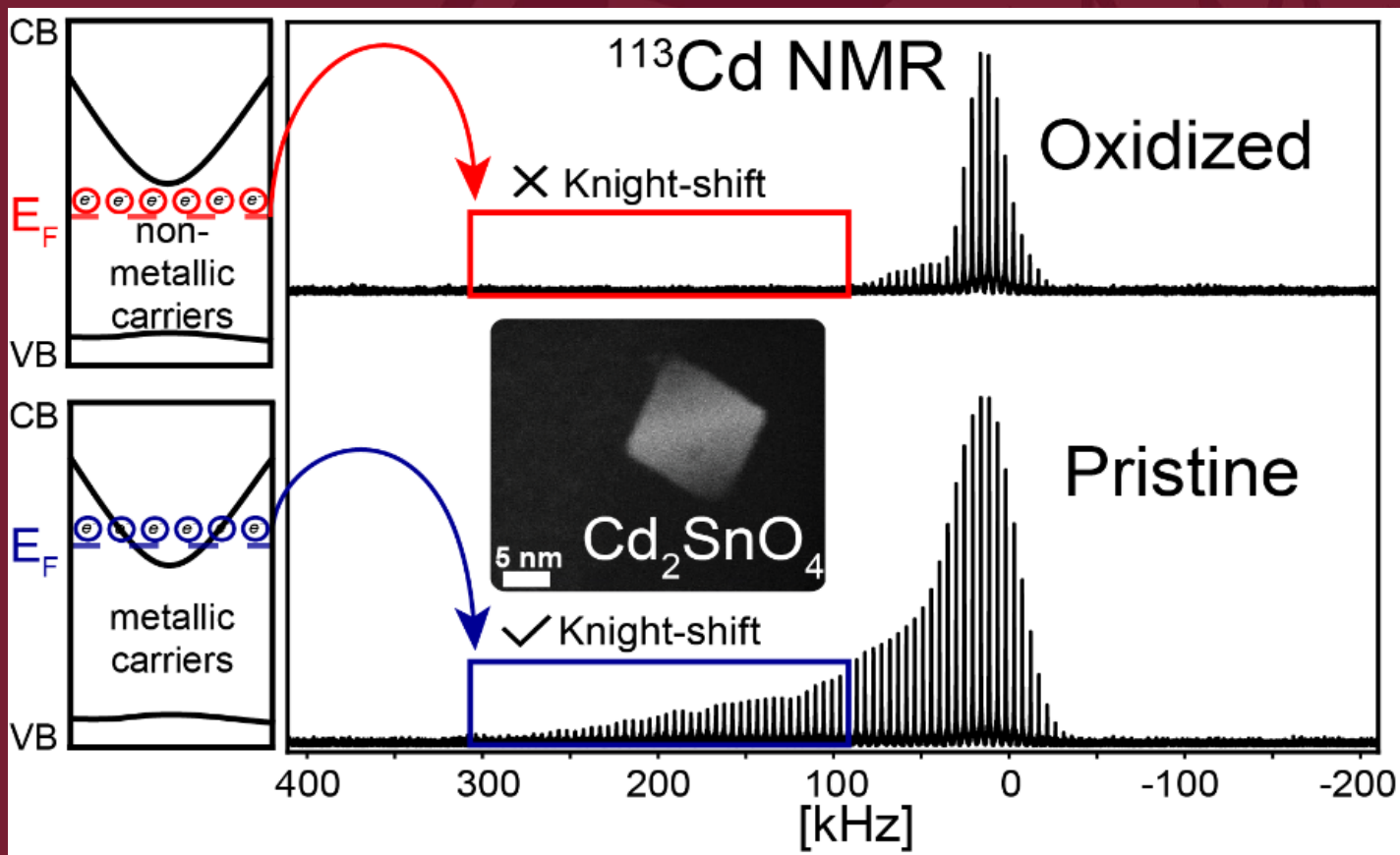
Can we prove it by chemically removing carriers in **CTO** using the 1-electron oxidant **NOBF₄**?





Can we be sure it is KS and not CS?

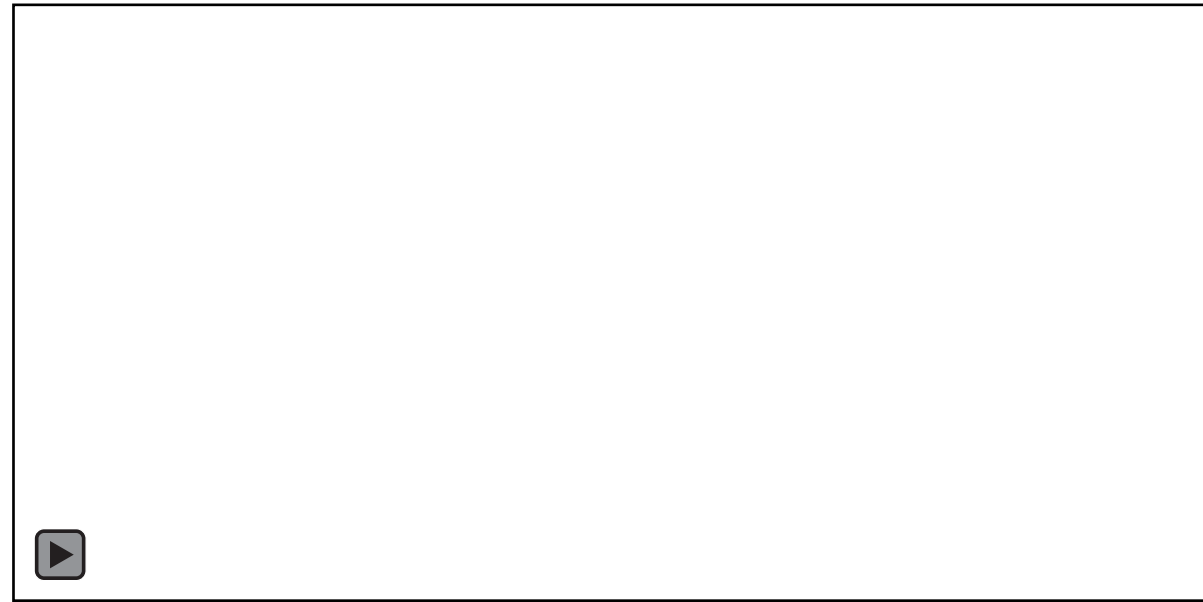
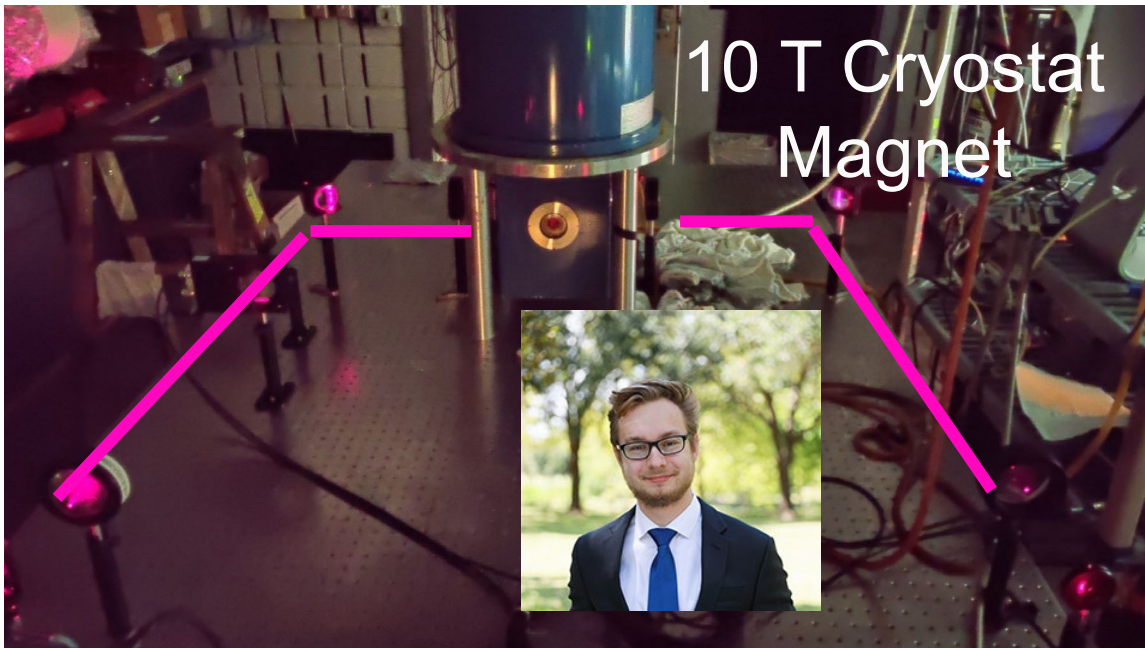
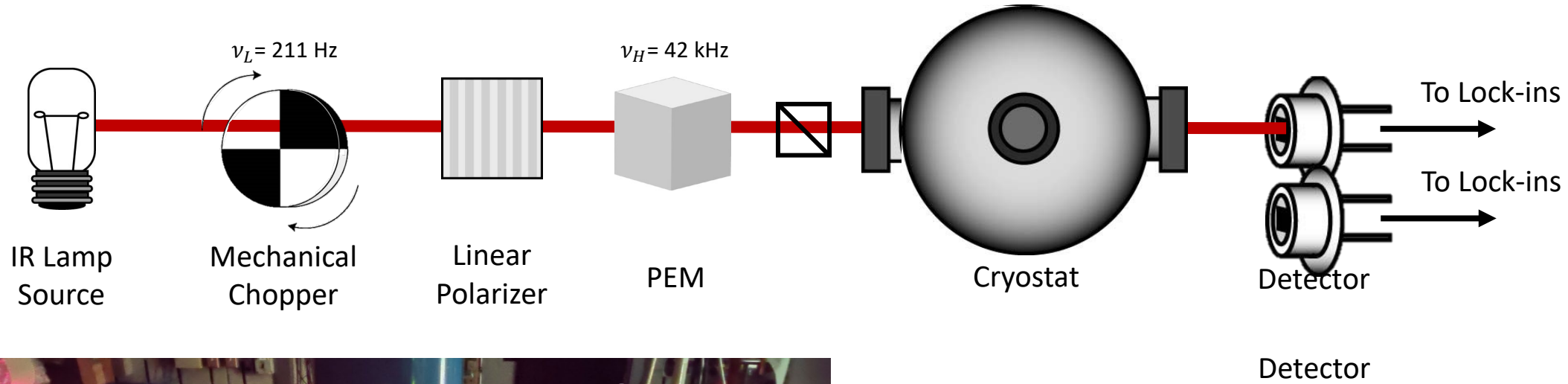
F-CTO Titrated with NOBF₄



Spectral change suggests shift arises from metallic like carriers (Knight shift) since CS is site dependent

$$KS \propto n^{1/3}$$

VT, VH-MCD Experiment

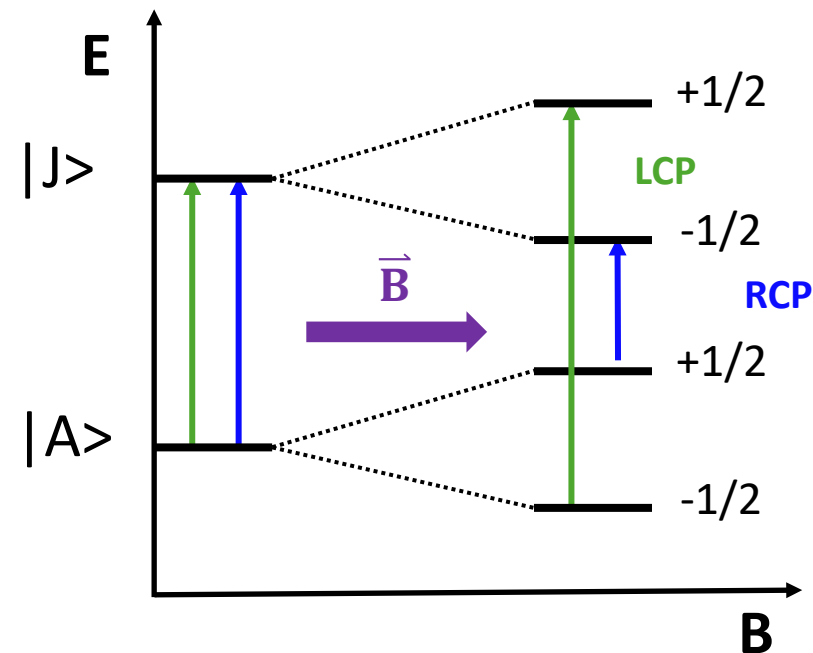
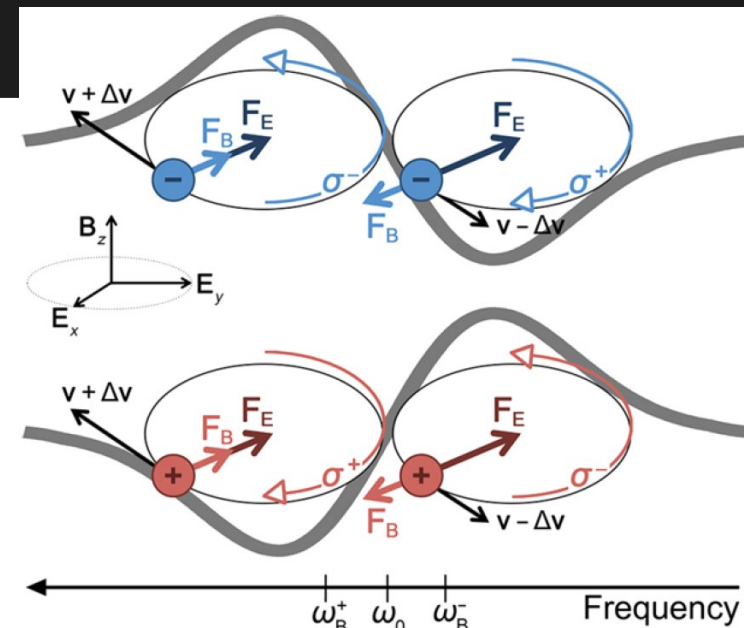
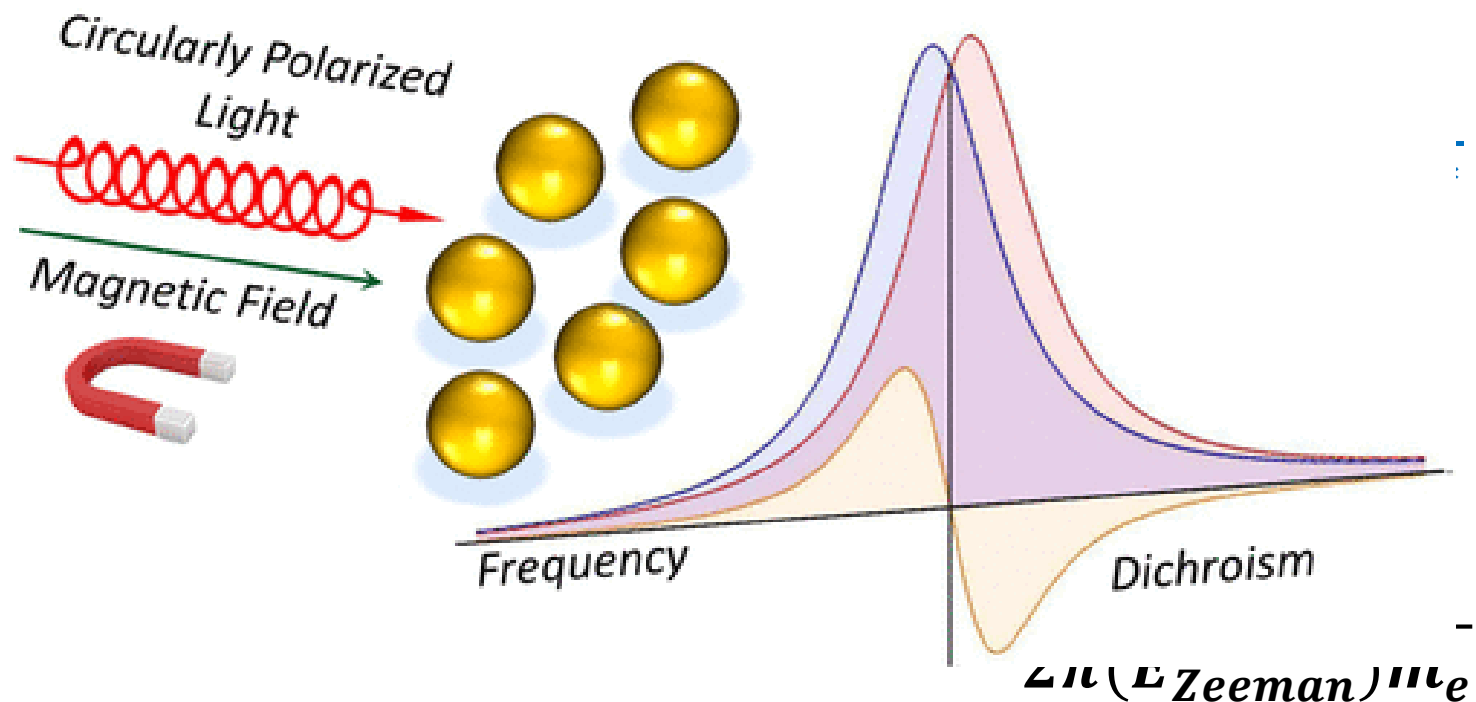


Magnetic Circular Dichroism (MCD)

Extraction of m^*

Cyclotron resonance

$$\omega_c = \frac{qB}{m^*m_e}$$

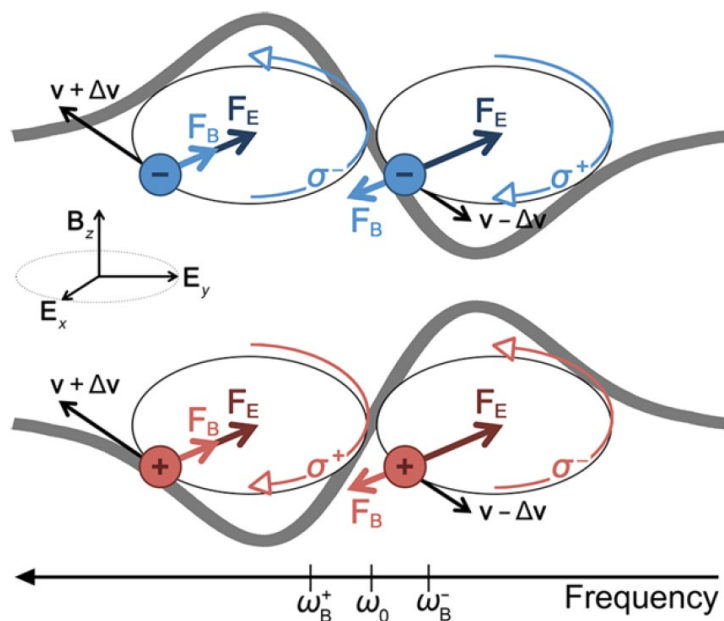
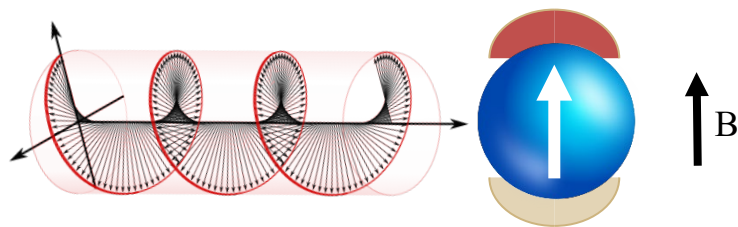


1. Pineider, F. et al, *Nano Lett.* **2013**
2. Hartstein, K. H. et al., *J. Phys. Chem. Lett.* **2017**
3. Kimura, T. and Hiroshi, Y., *J. Phys. Chem. C.* **2022**



Is this a question of trapping at donor levels due to V_0 ?

Then it should be reported as a change in m^* measured by MCD



$$\omega_B^{LCP/RCP} = \omega_0 \pm \frac{qB}{2m^*}$$

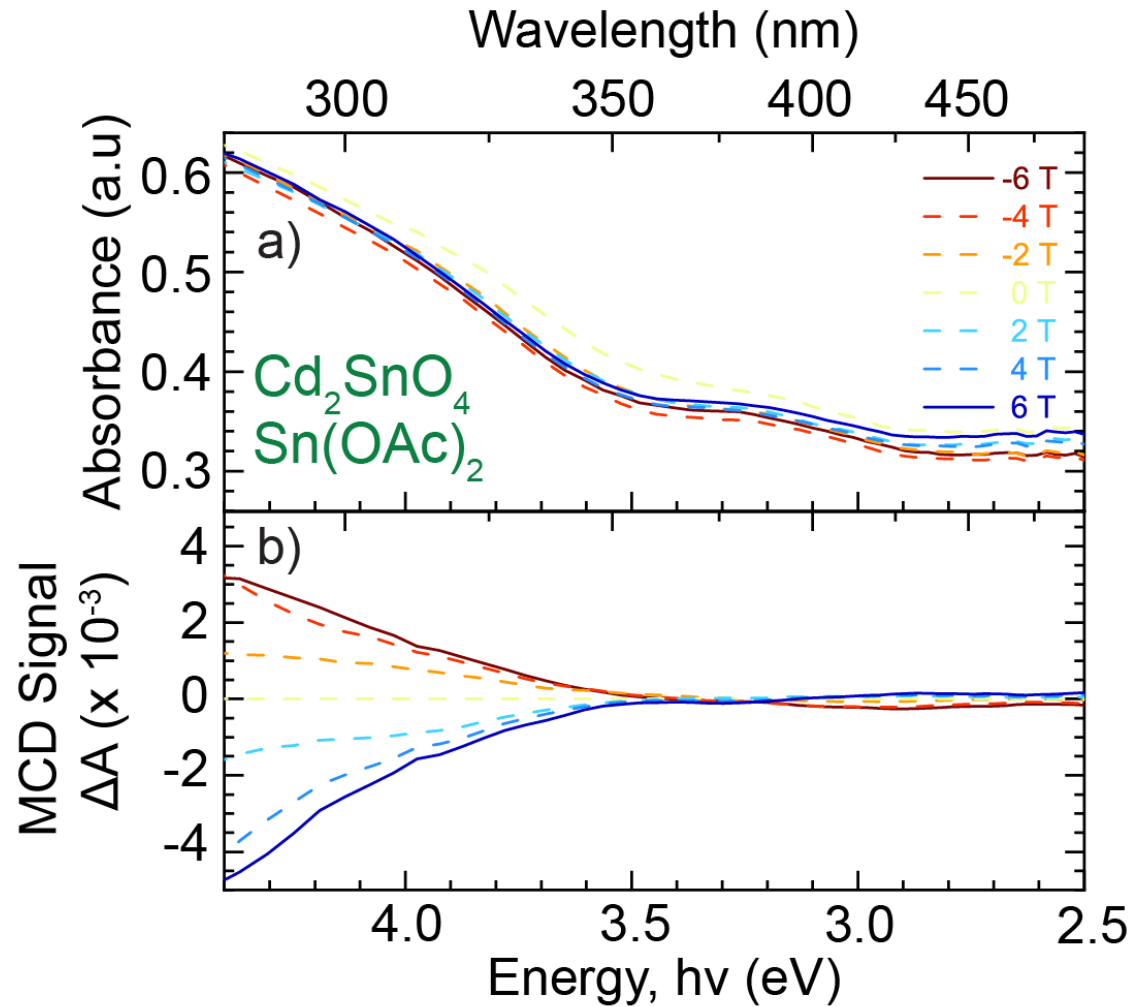
$$m^* = \frac{qBc}{2\pi(E_{Zeeman})m_e}$$

Pineider, F. et al, *Nano Lett.* **2013**

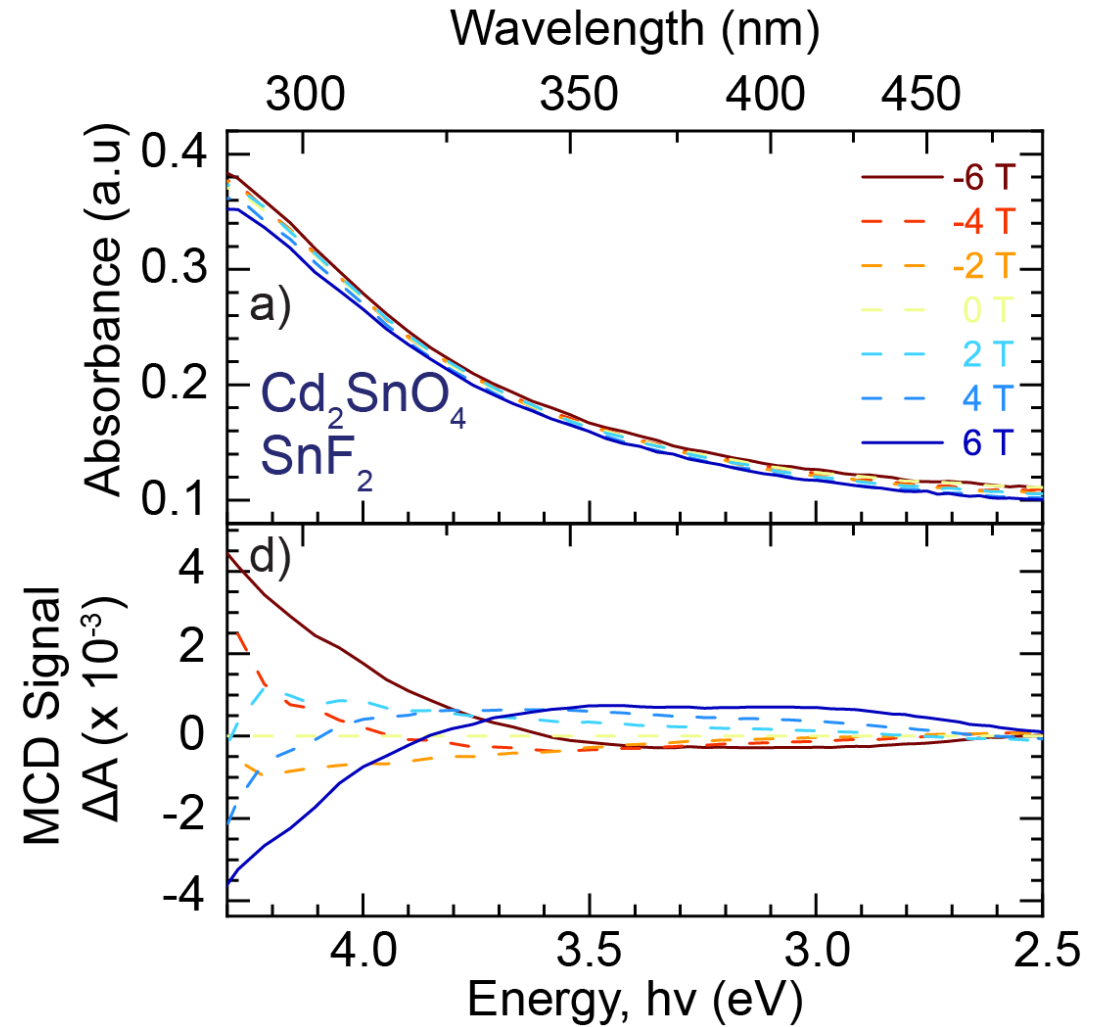
Hartstein, K. H. et al., *J. Phys. Chem. Lett.* **2017**

Kimura, T. and Hiroshi, Y., *J. Phys. Chem. C.* **2022**

Kuszynski, J., et al *J. Phys. Chem. C* **2022**



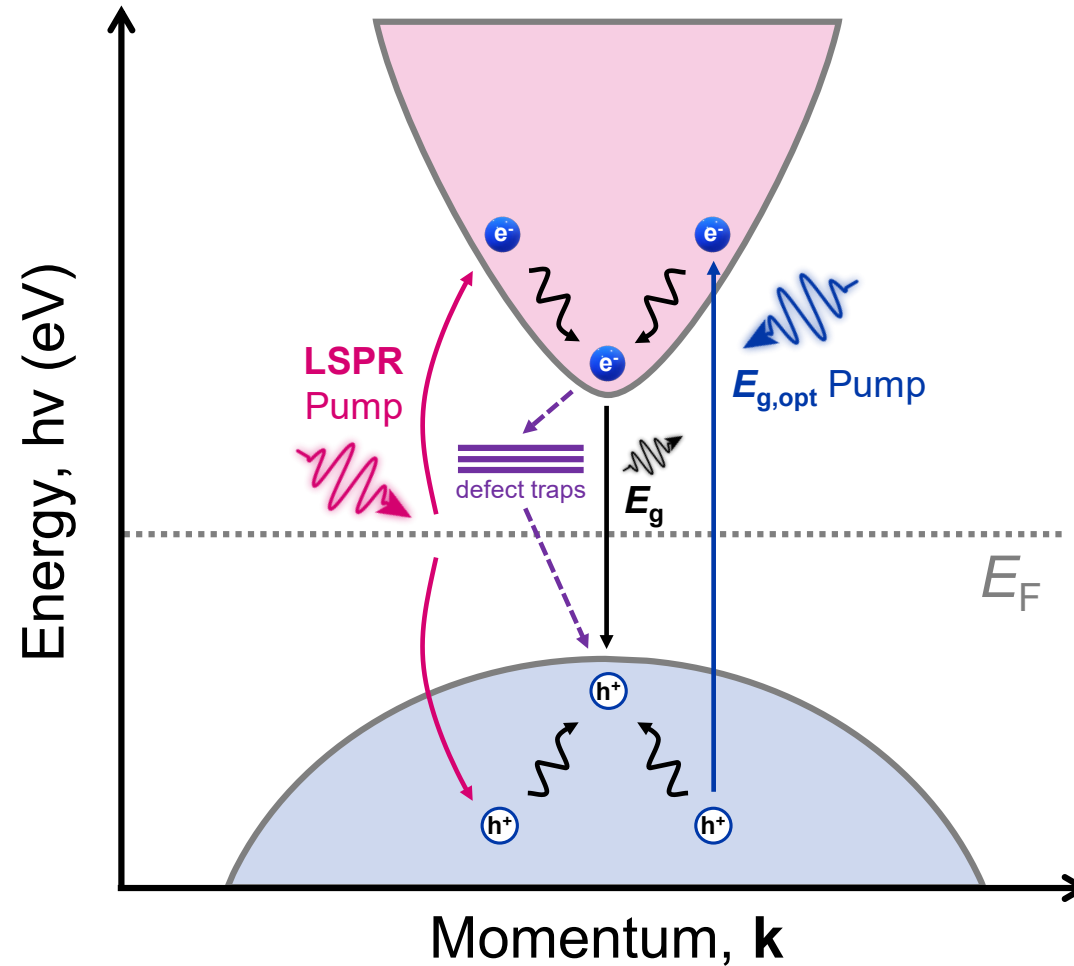
0.022 m^* for a-CTO



0.006 m^* for F-CTO



It will also show up in the LSPR Relaxation Processes

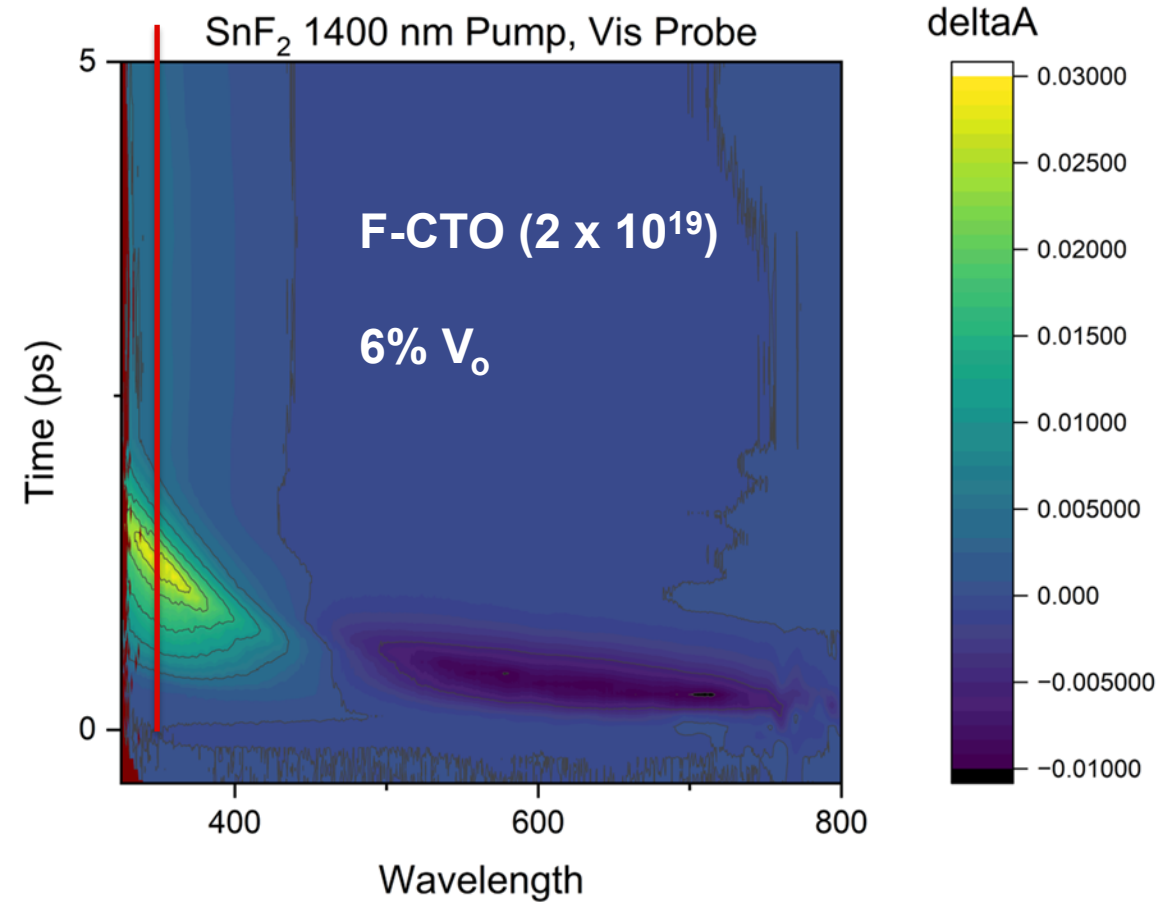
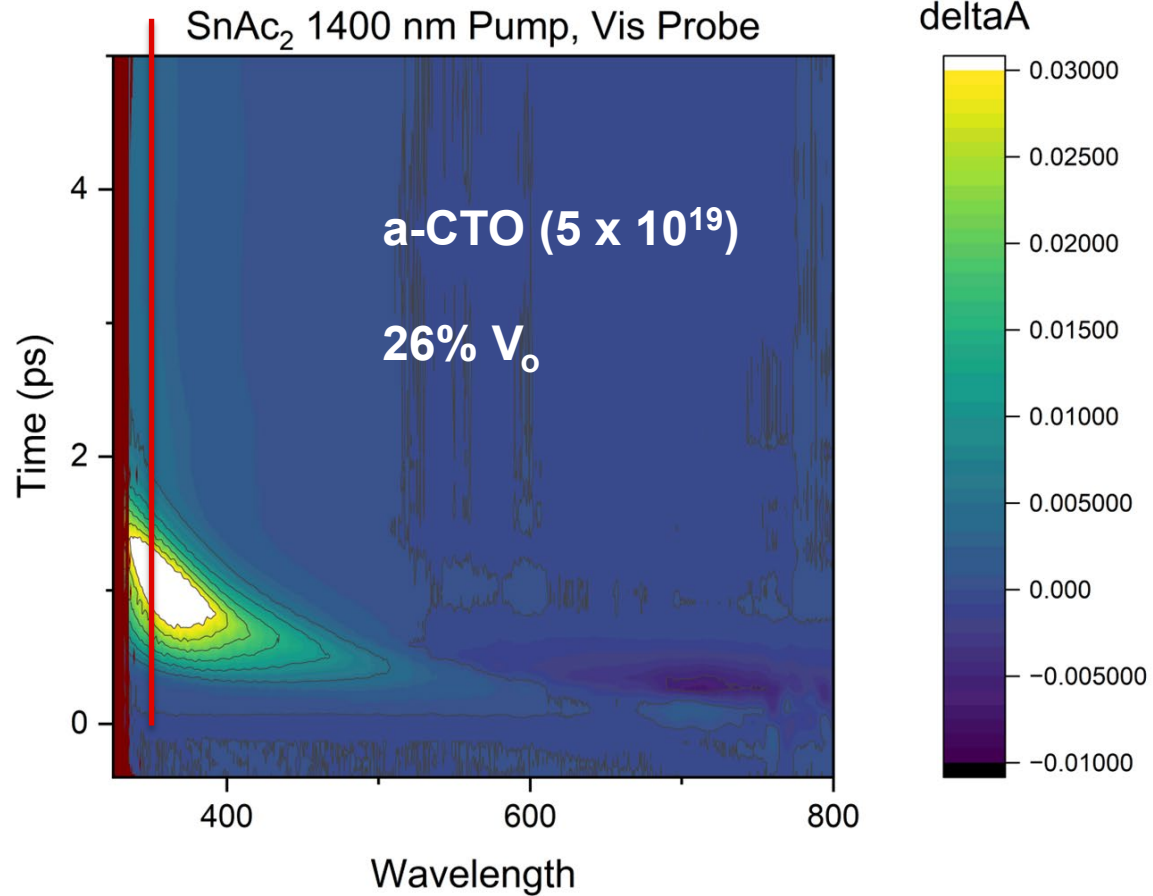




Cd₂SnO₄ fs-TA Data

350 nm Probe (0.99+ R² Fits)

LSPR Pump	Decay (fs)	Decay (ps)
SnAc ₂	184.0 ± 5.8	27.19 ± 3.95
SnF ₂	192.2 ± 6.4	99.51 ± 53.51





NSF-DMR #1905757



SMART
SCIENCE, MATHEMATICS,
AND RESEARCH FOR
TRANSFORMATION
PART OF THE NATIONAL
DEFENSE EDUCATION PROGRAM

Does carrier parentage matter?

- Sn_{cd} or V_{O} results in change in carrier mobility
 - (XPS, XSTM, TA, NMR and EPR T_1 and T_2)
- Site and lattice matter (lattice energies) – DFT
- Impacts w_{d} – surface interface damping
- Impacts LSPR damping/ hot carrier formation

- **Way more to do to fully understand carrier parentage in a PSNC**
shape, concentration, chemical interface damping, T-dependence,

